

The OSA Optoelectronics (PO) Technical Group Welcomes You!



COMPUTER-AIDED DESIGN OF
INTEGRATED PHOTONICS AND
OPTOELECTRONICS CIRCUITS

21 June 2019 • 12:00 EDT



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Technical Group at a Glance

- **Focus**

- This group's interests are in the field of semiconductor lasers, amplifiers, LEDs and super luminescent diodes.
- Over 4,500 members within OSA

- **Mission**

- To benefit YOU
- Webinars, e-Presence, publications, technical events, business events, outreach
- Interested in presenting your research? Have ideas for TG events? Contact winnie.ye@carleton.ca

- **Find us here**

- Website: www.osa.org/OptoelectronicsTG
- LinkedIn: www.linkedin.com/groups/8297718/

Today's Webinar



Computer-Aided Design of Integrated Photonics and Optoelectronics Circuits

Eugene Sokolov, MSc

Photonics Application Engineer

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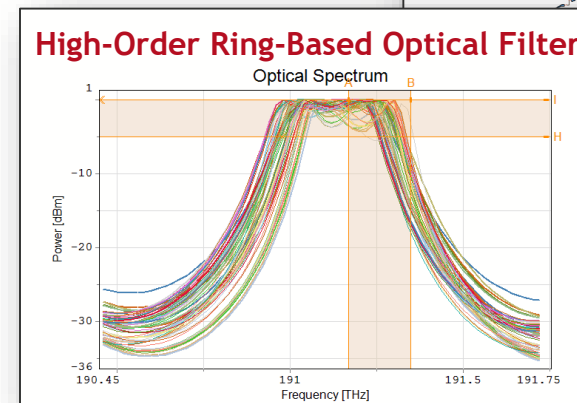
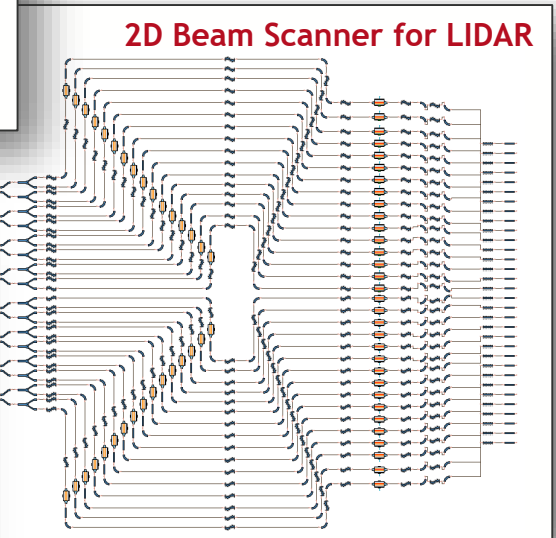
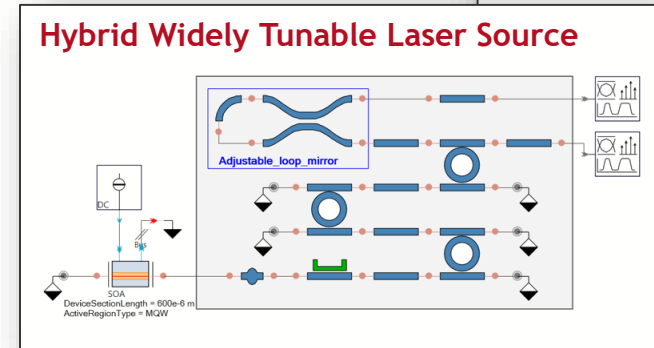
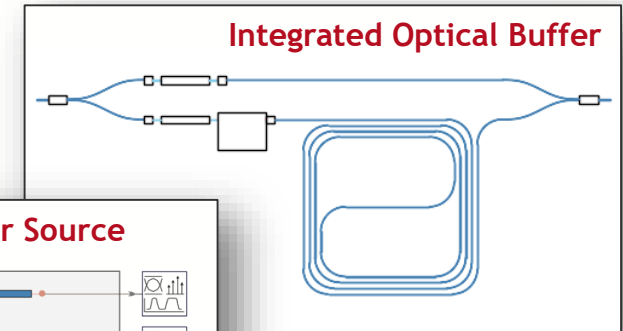


Computer-Aided Design of Integrated Photonics and Optoelectronics Circuits

Presenter: Eugene Sokolov

*OSA Optoelectronics Technical Group
21 June 2019*

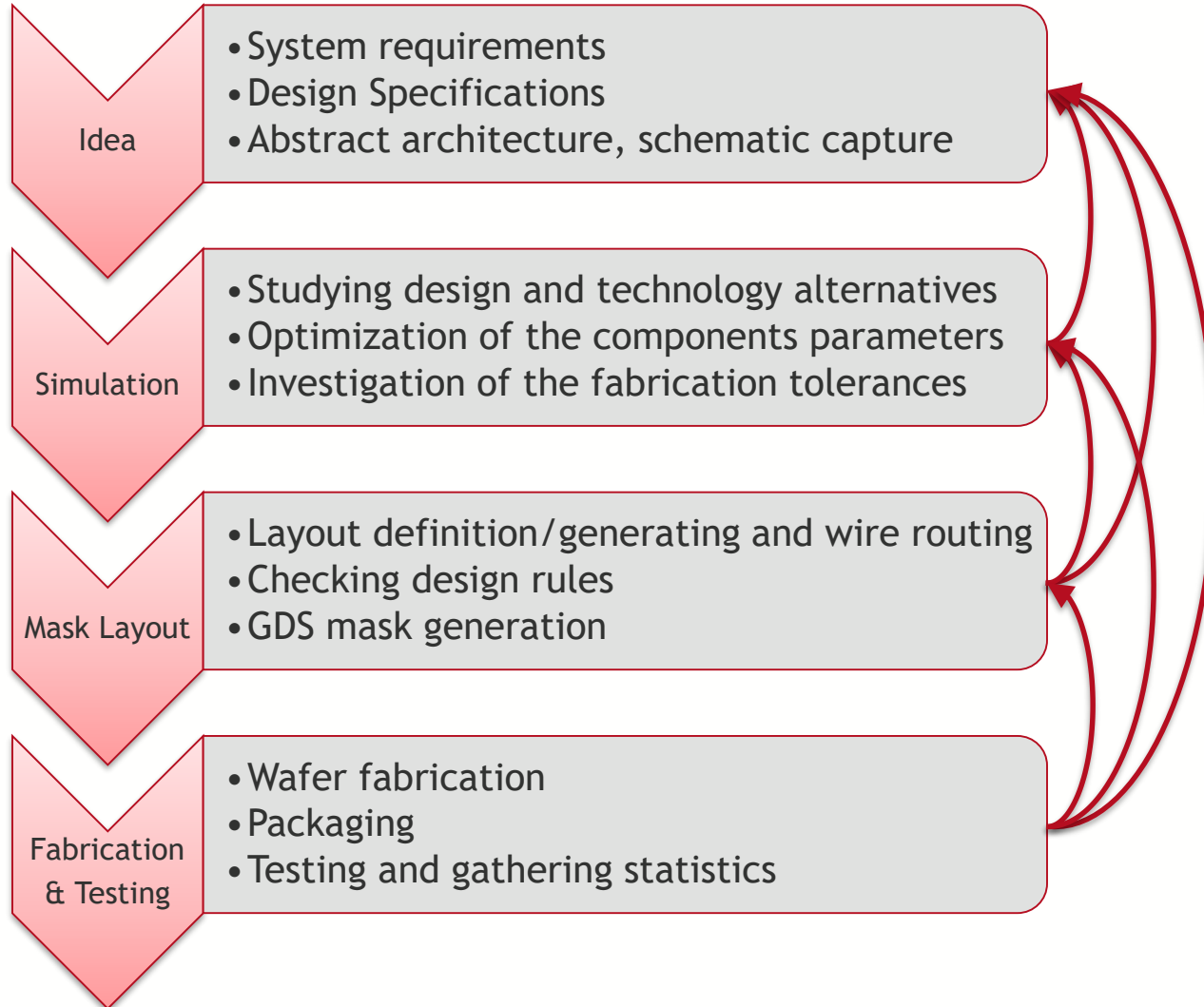
- Introduction
 - What is PIC Design
 - PIC Design Workflow 1997 vs. 2019
- The basics of circuit-level simulation
 - Passive and active components
 - Frequency-, Time- and Hybrid Domains
- Layout-aware design approach and PDKs
 - Introduction to Process Design Kits (PDKs)
 - Layout-aware simulations
- Design automation techniques
 - Simulating arrays and chains of modules
 - Scripting for schematic capture
 - Optimization and automated parameters settings
 - Design robustness & sensitivity analysis
- System-level performance verification



Introduction

- What is PIC Design
- PIC Design Workflow 1997 vs. 2019

Photonic Circuits Design Flow



choose the technology

meet the specifications

choose the components and set the parameters

With CAD SW Help!

agree the layout and the schematic

check that actual layout operates as expected

perform post-validation

compensate fabrication imperfections

The state of the art of CAD-tools in 1997*:

- Design architecture is mainly based on the designer's experience. It is first defined symbolically by text or by graphics.
- CAD tools mainly focus on the analysis of waveguide devices and utilizes mode solvers and BPM methods.
- Setting of the components parameters is iterative and is frequently gambling. Parameter scans and the use of optimization algorithms are not common.
- There are accuracy problems at various levels in the design process, which results in multiple trials and errors in fabrication loop.
- As CAD-methods move to 3D and/or vectorial problems, the calculation time increases.
- When active devices are involved, the optical field modelling needs to be combined with electrical and/or thermal modelling.

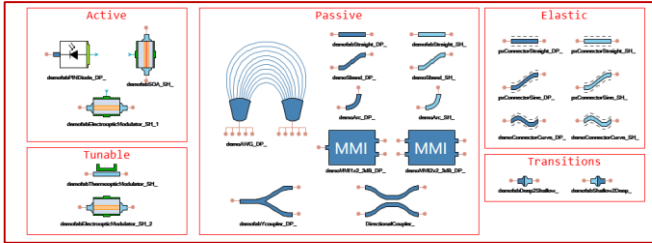
*R. Baets and D. Van Thourhout, "Computer aided design for integrated optical circuits: task flow and tools," *Conference Proceedings. LEOS '97. 10th Annual Meeting IEEE Lasers and Electro-Optics Society 1997 Annual Meeting*, San Francisco, CA, USA, 1997, pp. 397-398 vol.1.

Solution Proposed*:

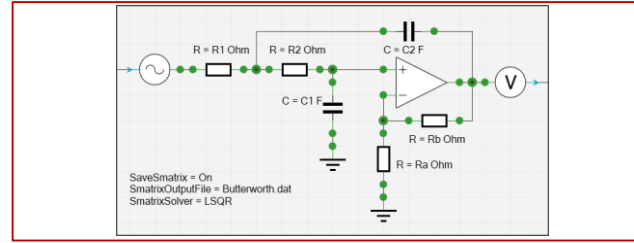
- Creation of expert system tools which store information about basic elements, validated by numerical simulations or experiments. Emphasis not on field calculation but rather on combining and manipulating previously obtained information.
- Employing an S-matrix approach for more complex circuits
- Interfaces to mode solvers, BPMs, etc. with easy transformation of the results into the tables or formulas for future use
- Standardization of the data formats for exchange between the tools
- Automated mask layout generation

*R. Baets and D. Van Thourhout, "Computer aided design for integrated optical circuits: task flow and tools," *Conference Proceedings. LEOS '97. 10th Annual Meeting IEEE Lasers and Electro-Optics Society 1997 Annual Meeting*, San Francisco, CA, USA, 1997, pp. 397-398 vol.1.

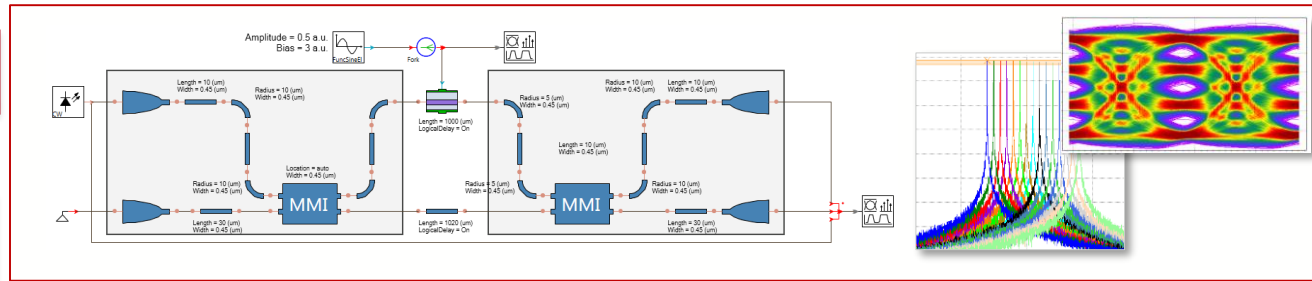
PDK Building Block Libraries



Electronic Design Automation



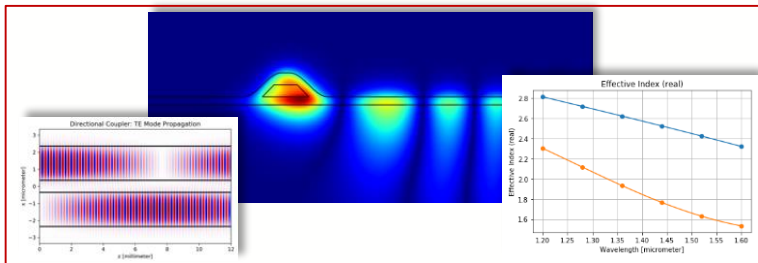
Photonic Circuit Simulation & System Validation



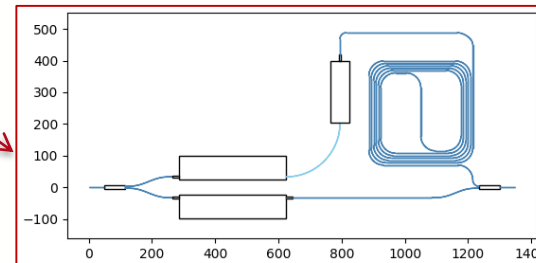
Optoelectronics and electrical simulation

Foundry-specific models
Extract device parameters

Device Modeling



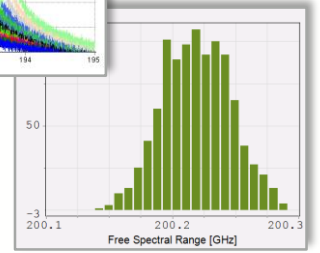
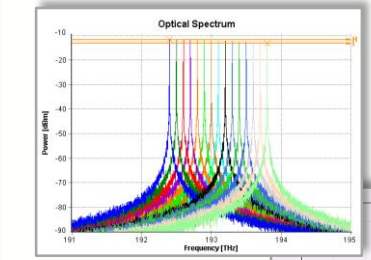
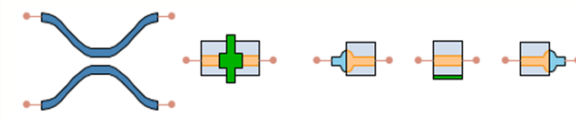
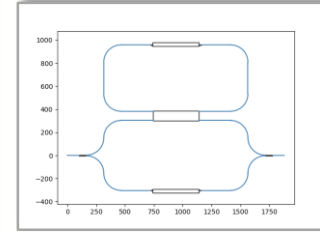
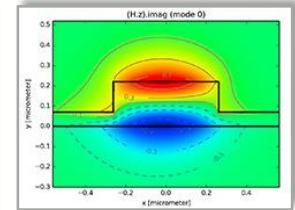
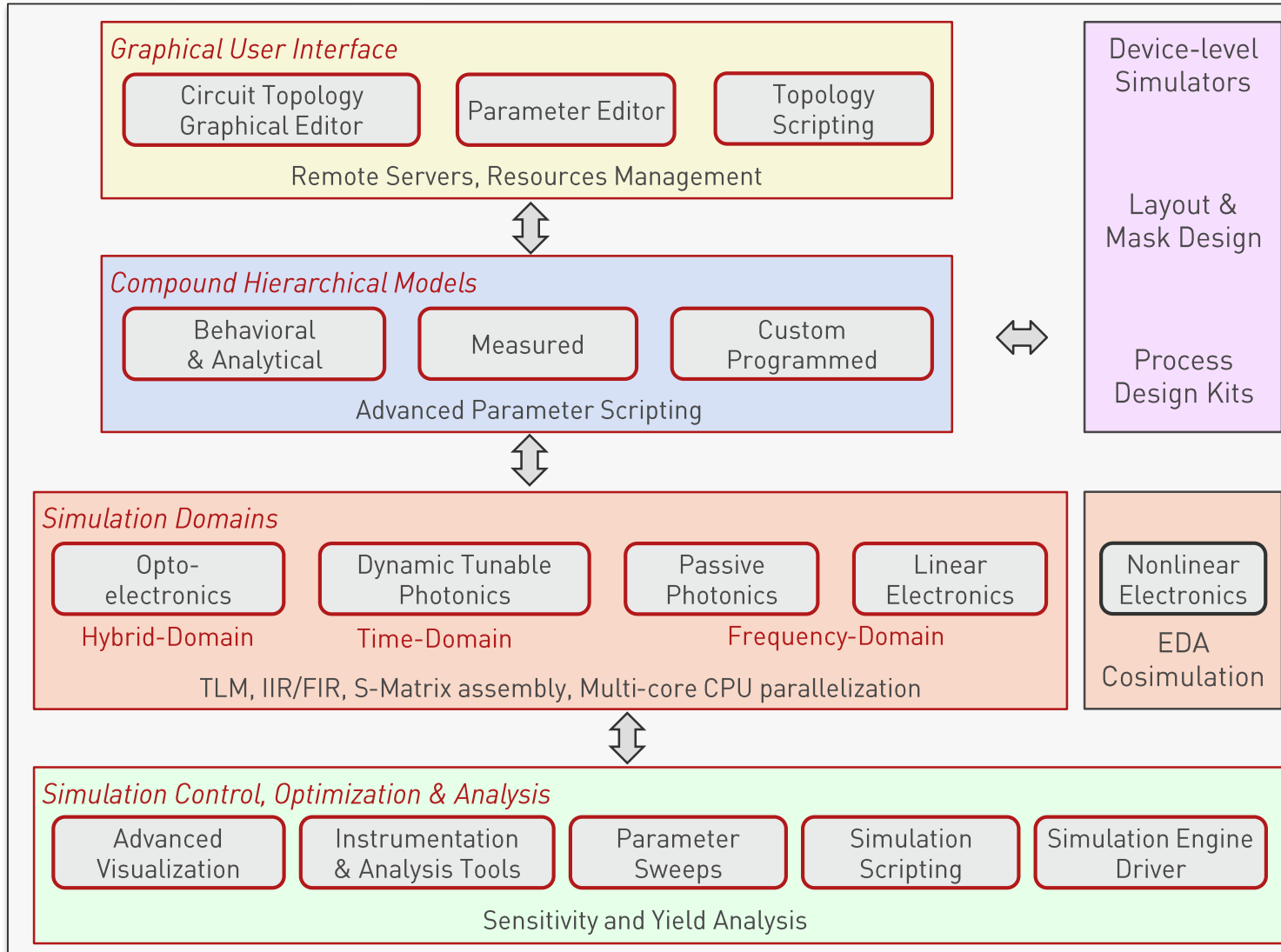
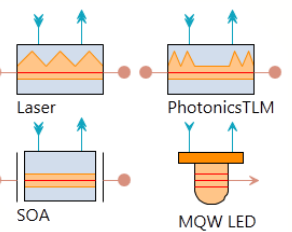
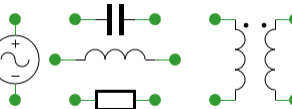
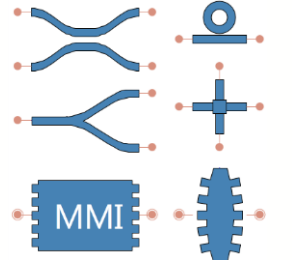
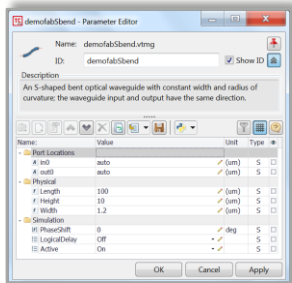
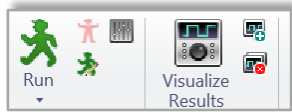
Layout Design



Layout design & DRCs, verification of layout

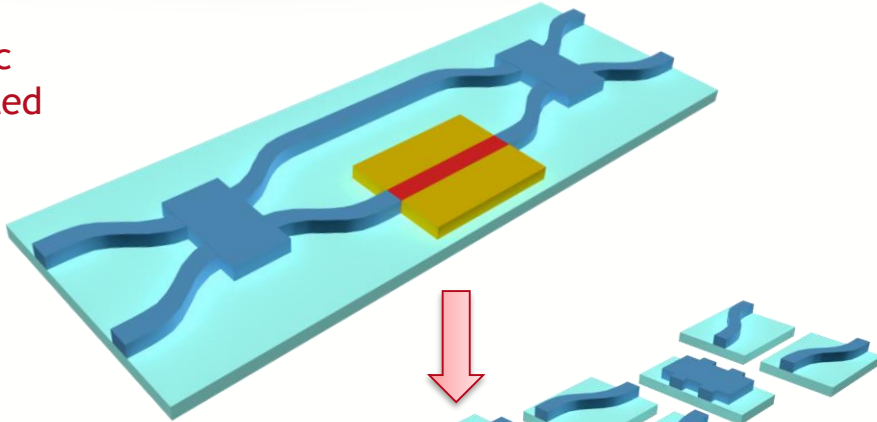
The basics of circuit-level simulation

- Passive and active components
- Frequency-, time- and hybrid time-and-frequency domains
- Design Example: Widely Tunable Laser Source

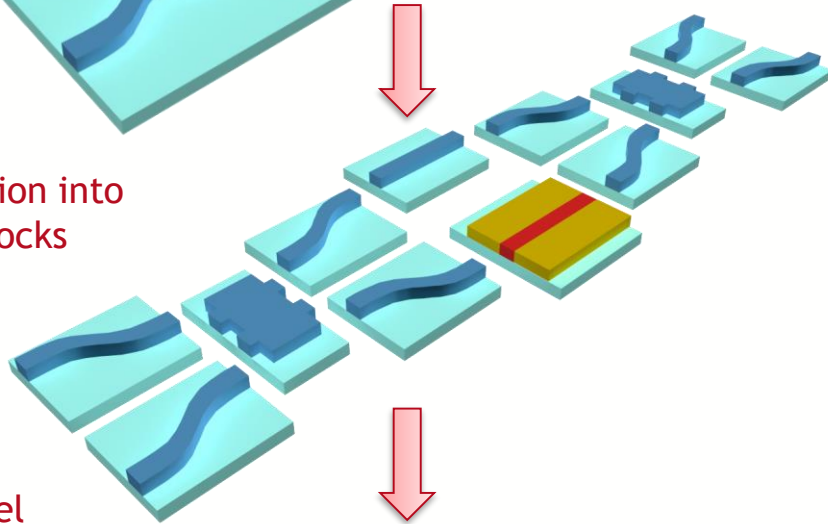


System-Level Abstraction of Photonic Circuits

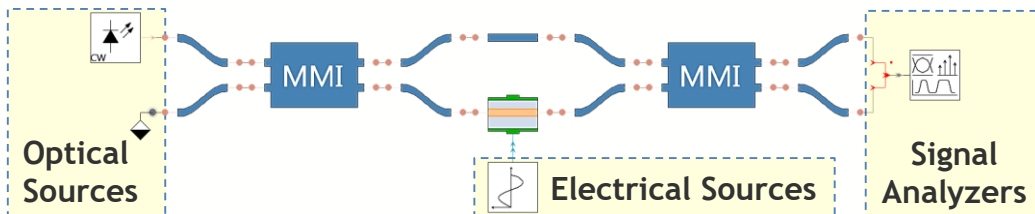
Photonic Integrated Circuit



Segmentation into Building Blocks



Circuit-level Simulation

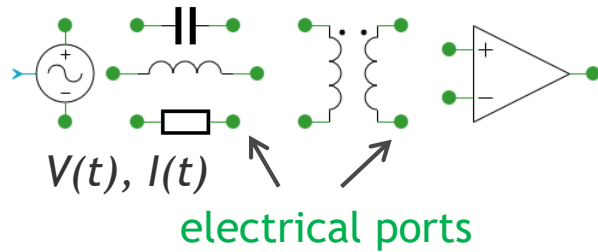


- Circuit-level simulation of a PIC is separated from device-level modeling of its BBs
- Individual BBs can be modeled by different methods, providing easy balance between accuracy and speed requirements
- This approach enables efficient design of large-scale PICs, made of many hundreds BBs
- Scalable circuit-level simulation techniques are required

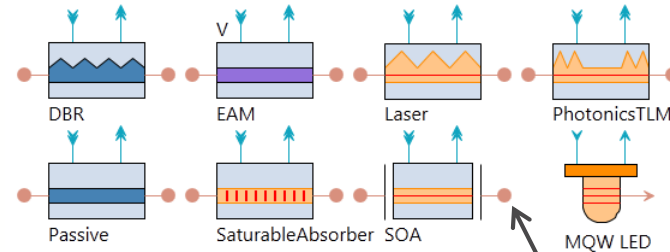
Models & Simulation Parameters				
Name	Value	Unit	Type	
Physical				
ModelType	EffectiveIndex		S	<input type="checkbox"/>
f Length	1000e-6	m	S	<input type="checkbox"/>
f ModeCouplingCoefficient	0.0	1/m	S	<input type="checkbox"/>
EffectiveIndexDefinition	Parameters		S	<input type="checkbox"/>
f ReferenceFrequency	193.1e12	Hz	S	<input type="checkbox"/>
f EffectiveIndex	2.6		S	<input type="checkbox"/>
f GroupIndex	4.2		S	<input type="checkbox"/>
f Dispersion	0.0	s/m ²	S	<input type="checkbox"/>

BB - Building Block

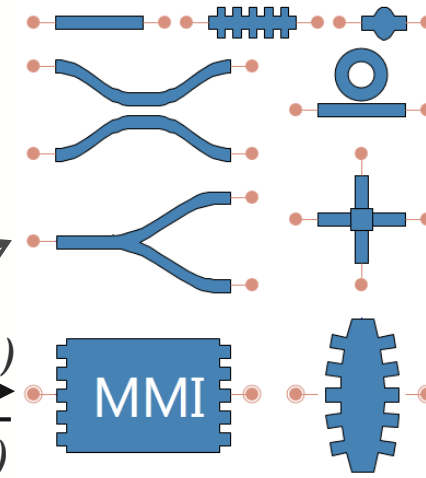
Electronic Elements



Optoelectronic Elements



Photonic Elements



optical ports

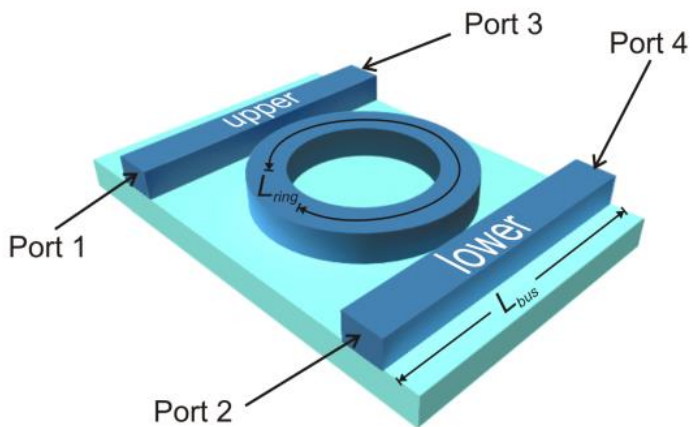
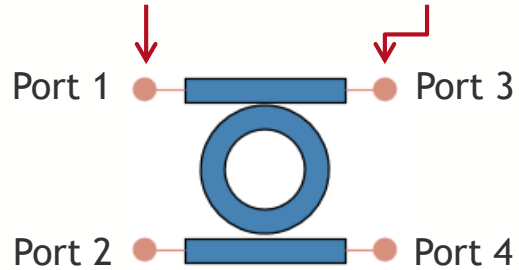
- ⇒ *Large diversity* of basic elements
many photonic/optoelectronic devices are *spatially distributed!*
- ⇒ Electrical and *optical signals*

complex-valued amplitudes

$$\vec{E}(\vec{r}_\perp, t) = \sum_{\nu, \mu} \{ A_{\nu, \mu}(t) \vec{F}_\nu(\vec{r}_\perp, \omega_\mu) e^{j\omega_\mu t} + B_{\nu, \mu}(t) \vec{F}_\nu^*(\vec{r}_\perp, \omega_\mu) e^{j\omega_\mu t} \} + c. c.$$

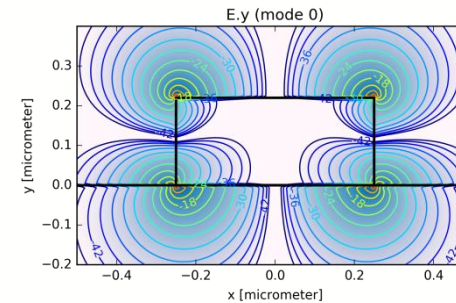
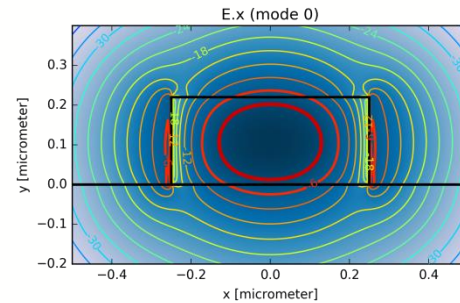
- ⇒ *Complex compact models*
governed by partial differential and integro-differential equations for time-domain simulations

Ports for communication with other modules.
Bidirectional ports may both generate and accept signals

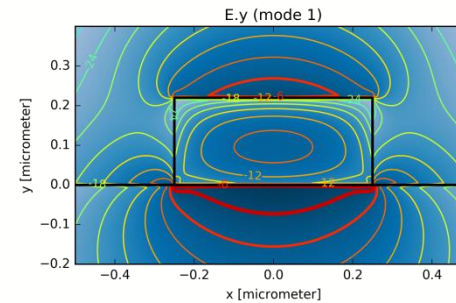
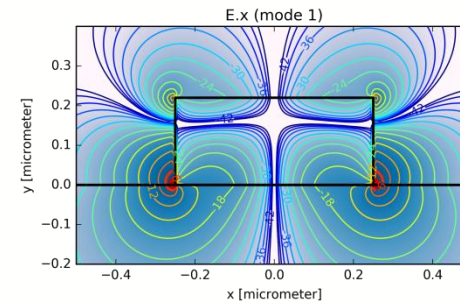


Each optical port is a piece of optical waveguide or fiber:

Waveguide modes:



TE-like mode
(X-polarization)



TM-like mode
(Y-polarization)

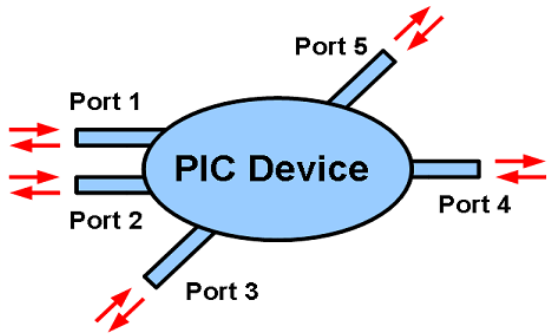
Modulation frequency \ll Optical carrier frequency \Rightarrow complex-envelope baseband transformation

$$\vec{E}(\vec{r}_\perp, t) = \sum_{\nu, \mu} \left\{ \overset{\text{complex-valued}}{\underset{\text{Forward waves}}{A_{\nu, \mu}(t)}} \vec{F}_\nu(\vec{r}_\perp, \omega_\mu) e^{j\omega_\mu t} + \overset{\text{complex-valued}}{\underset{\text{Backward waves}}{B_{\nu, \mu}(t)}} \vec{F}_\nu^*(\vec{r}_\perp, \omega_\mu) e^{j\omega_\mu t} \right\} + c.c.$$

$$\omega_\mu = 2\pi f_\mu \text{ are carrier frequencies } (\sim 200 \text{ THz})$$

S-Matrix Description of Passive PIC Elements

- Passive photonic circuits and devices are considered as black boxes with N ports and are completely characterized by a scattering matrix (S-Matrix)
- S-Matrix of a device with N bidirectional two-mode ports consists of 2N x 2N matrix of complex-valued frequency-dependent transfer functions
- Each transfer function relates complex amplitude of optical signal carried by guided TE/TM modes traveling towards the device port n with the one traveling away from the device port m



S-Matrix: describes transfer functions between all ports

$$\hat{S}(f) = \begin{pmatrix} \hat{T}_{11}(f) & \cdots & \hat{T}_{1N}(f) \\ \vdots & \hat{T}_{mn}(f) & \vdots \\ \hat{T}_{N1}(f) & \cdots & \hat{T}_{NN}(f) \end{pmatrix}$$

Jones Matrix: connects waves at input port n and output port m

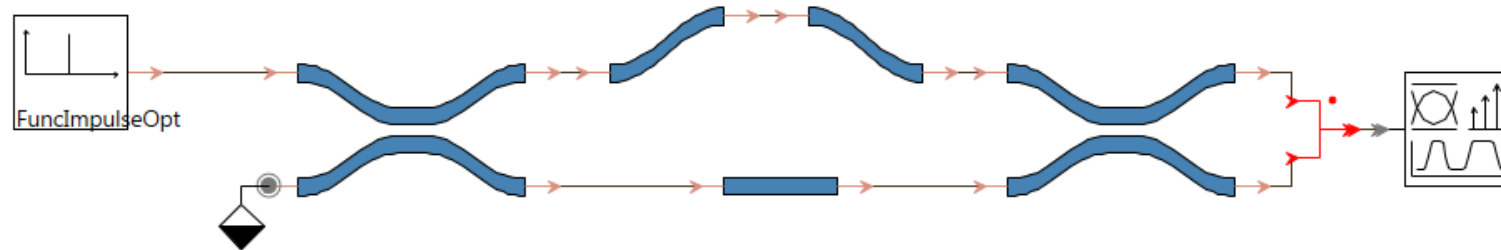
$$\hat{T}_{mn}(f) = \begin{pmatrix} T_{mn}^{TE,TE} & T_{mn}^{TE,TM} \\ T_{mn}^{TM,TE} & T_{mn}^{TM,TM} \end{pmatrix}$$

Transfer Function: connects waves at given input and output ports & modes

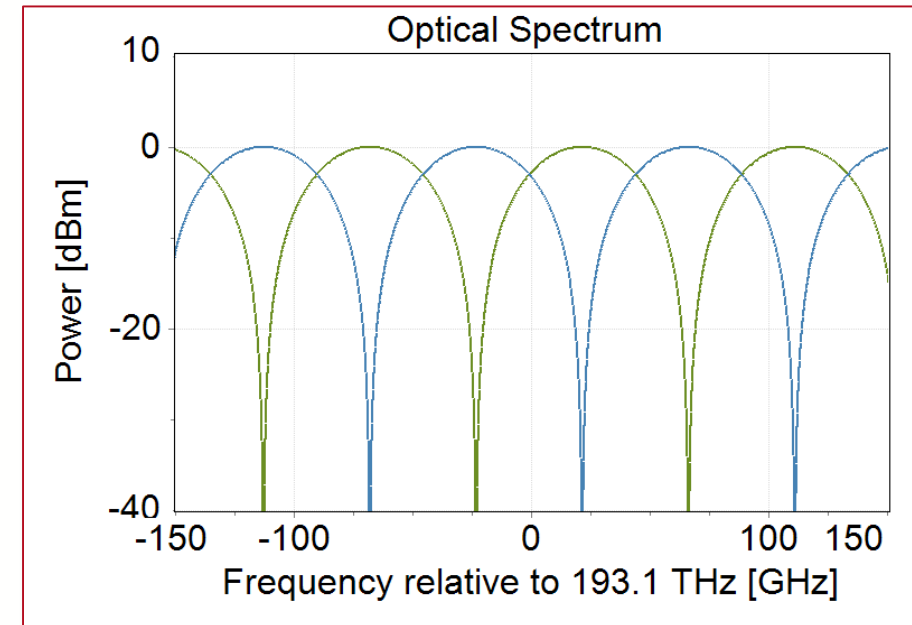
$$T_{mn}^{TE,TM}$$

$$\begin{pmatrix} \vec{E}_1^{out}(f) \\ \vec{E}_2^{out}(f) \\ \cdots \\ \vec{E}_M^{out}(f) \end{pmatrix} = \hat{S} \begin{pmatrix} \vec{E}_1^{in}(f) \\ \vec{E}_2^{in}(f) \\ \cdots \\ \vec{E}_N^{in}(f) \end{pmatrix}$$

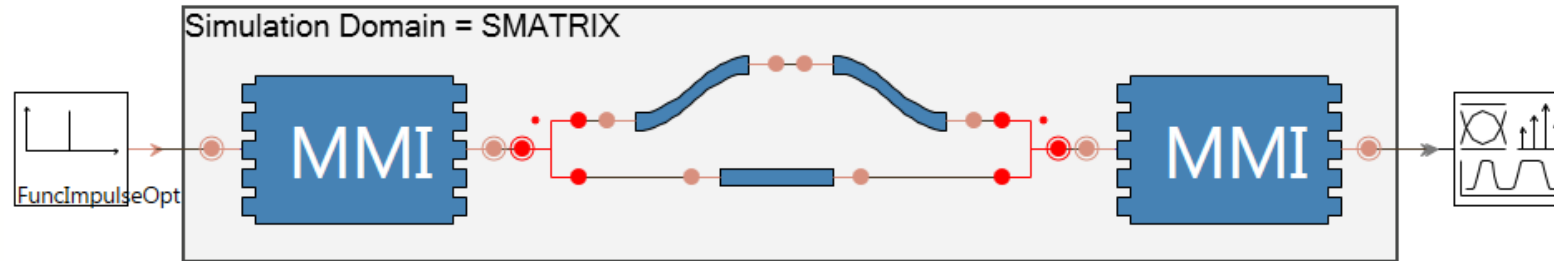
Simple Example: Unbalanced MZI



- For unidirectional signal flow signal is filtered in steps by individual S-matrices
- Simulation is performed in the frequency domain



Simple Example: Unbalanced MZI with Reflections



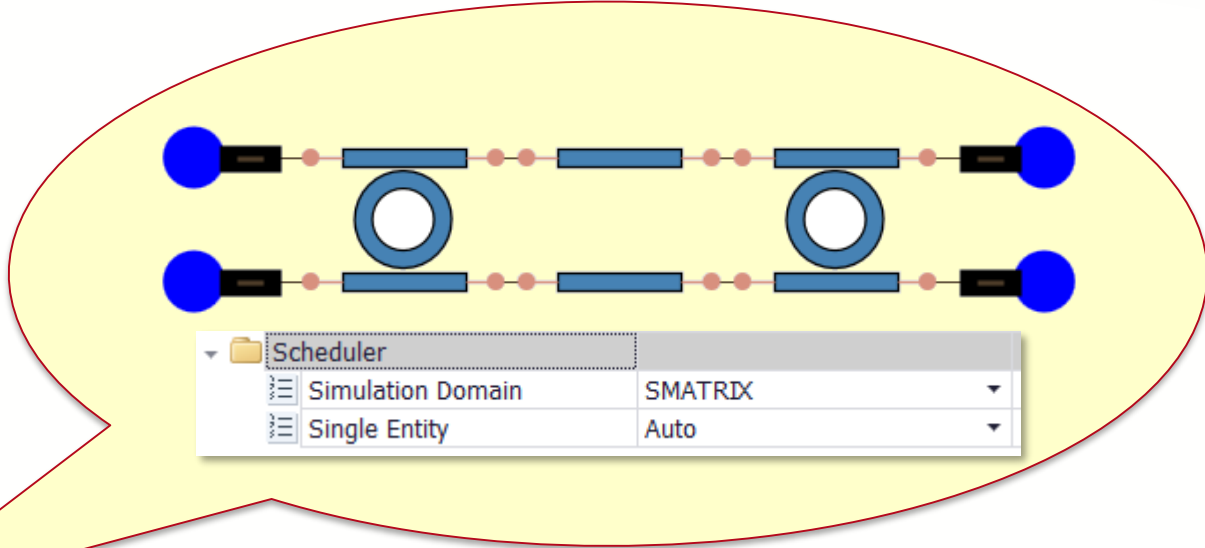
- Multi-mode interference (MMI) devices could partially reflect optical signals
- Bidirectional signal flow is required
- Compound models approach

Compound Models of Passive PIC Elements

first step to scalability!

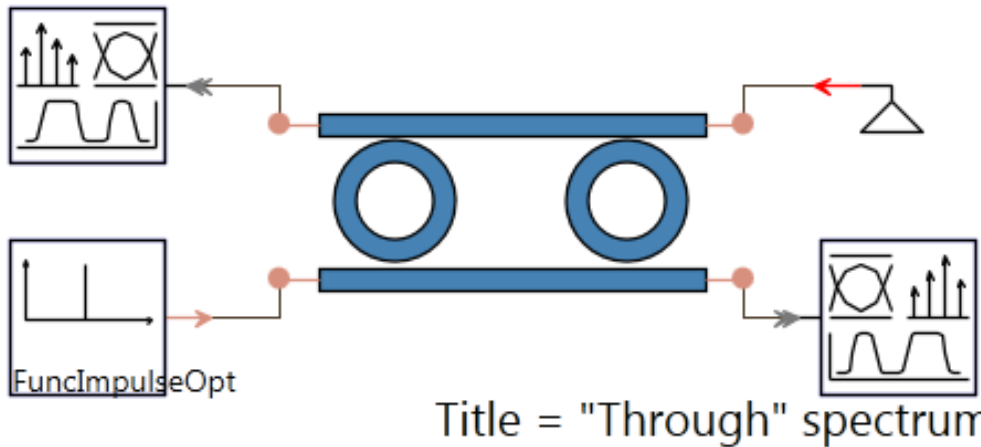
SMATRIX-domain galaxy

Assemble S-Matrices of individual sub-elements and operate with the S-Matrix of the whole circuit as a single-entity passive PIC device



Hierarchical design

Title = "Drop" spectrum



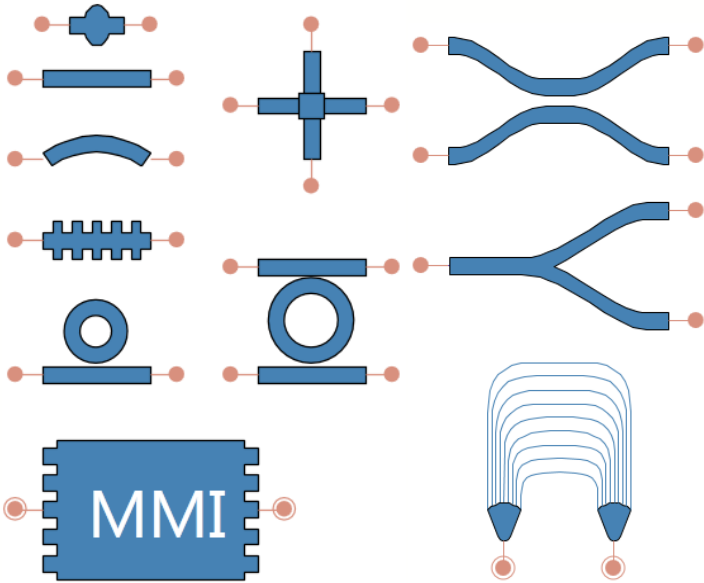
S-matrix assembly

$$\hat{S}_{PIC}(f) = \hat{S}_1(f) \otimes \hat{S}_2(f) \otimes \dots \otimes \hat{S}_{N-1}(f) \otimes \hat{S}_N(f)$$

- S-matrix of the whole device is calculated before signal processing involving solving a sparse system of linear equations
- Fastest S-matrix assembly algorithm is automatically chosen

Built-in PIC Elements

S-Matrix from analytical models

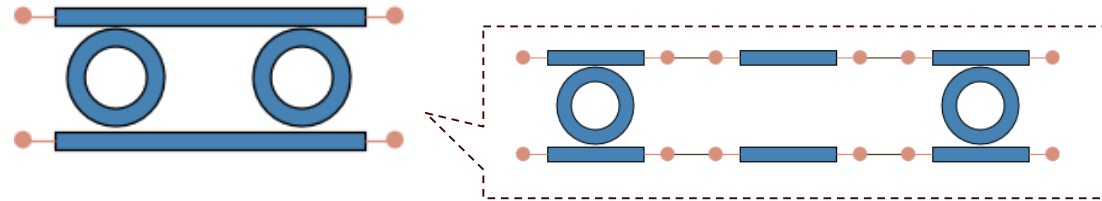


Measured Models

S-Matrix for an element of any type loaded from file

Compound PIC Elements

S-Matrix calculated on-the-fly using assembly techniques

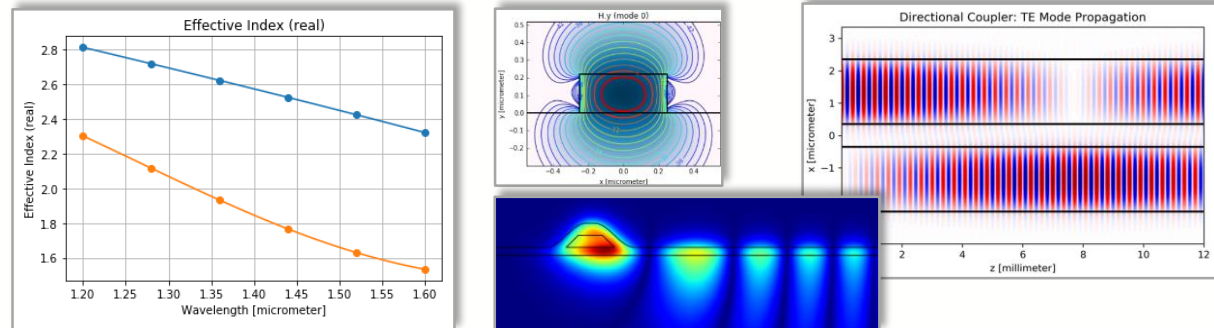


Co-simulated PIC Elements

S-Matrix defined in Python or C/C++

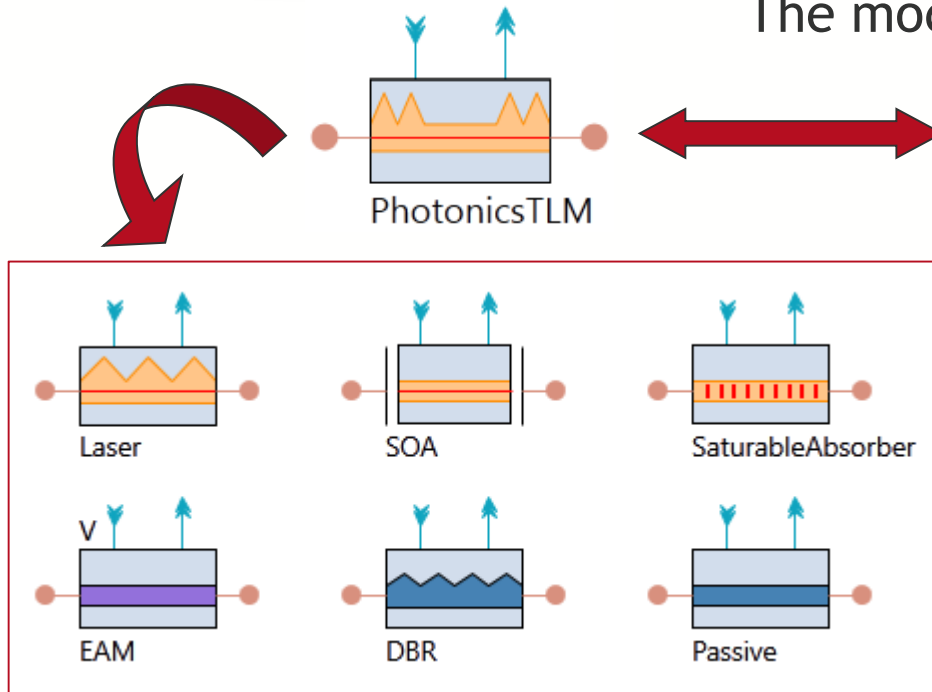
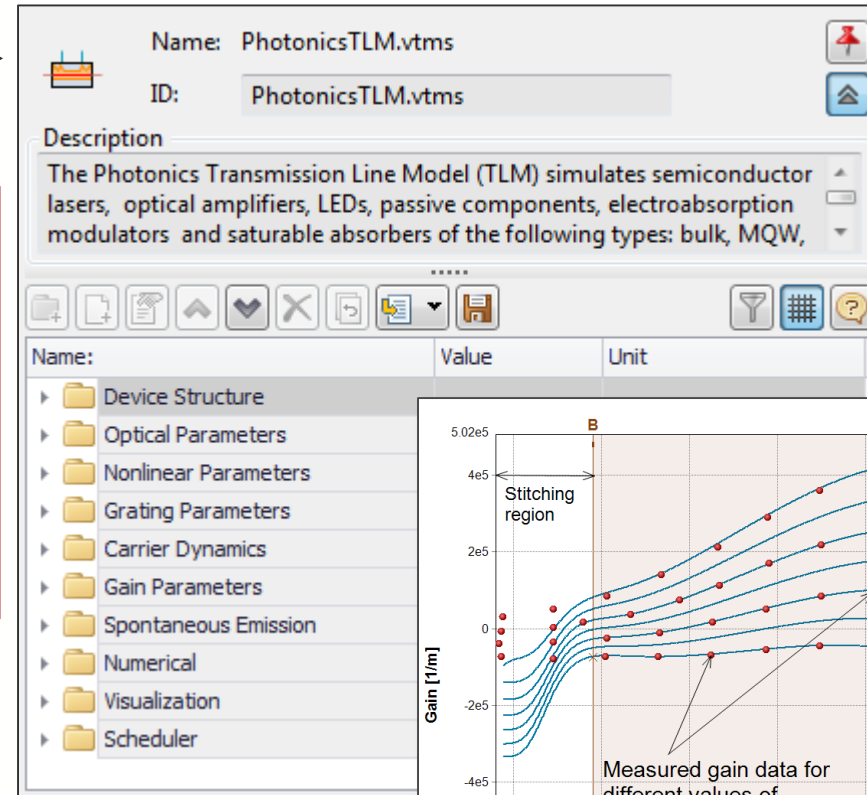


Calculated by Device Level Simulators



All these elements can be easily combined to form larger structures!

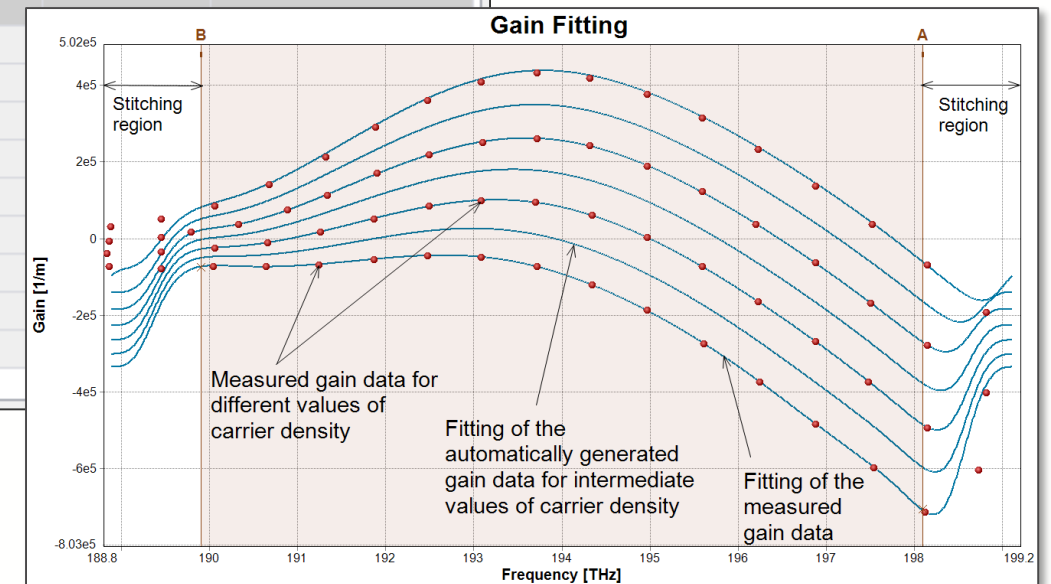
The models usually are much more complicated and diverse

Name: PhotonicsTLM.vtms
ID: PhotonicsTLM.vtms

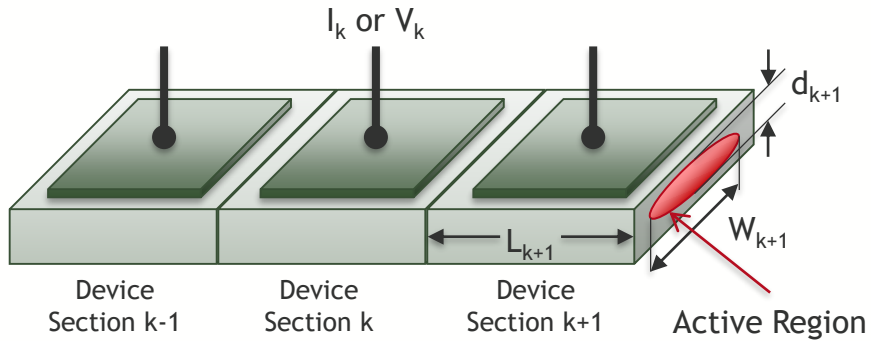
Description
The Photonics Transmission Line Model (TLM) simulates semiconductor lasers, optical amplifiers, LEDs, passive components, electroabsorption modulators and saturable absorbers of the following types: bulk, MQW,

Name:	Value	Unit
Device Structure		
Optical Parameters		
Nonlinear Parameters		
Grating Parameters		
Carrier Dynamics		
Gain Parameters		
Spontaneous Emission		
Numerical		
Visualization		
Scheduler		

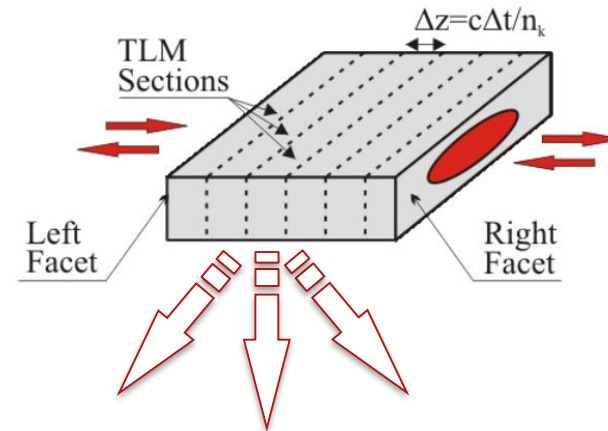


- Bidirectional ports
- Nonlinear effects (Kerr, TPA)
- Index & gain Bragg gratings
- Single-section and multi-section devices

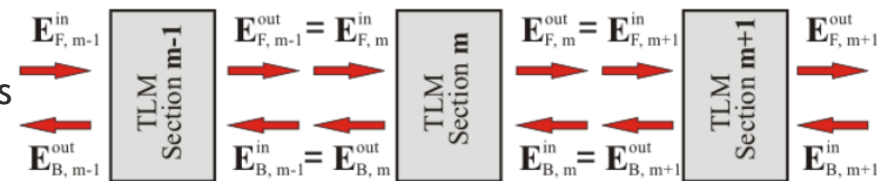
Semiconductor Cavity



Device Section k



Photonics Transmission-Line Model

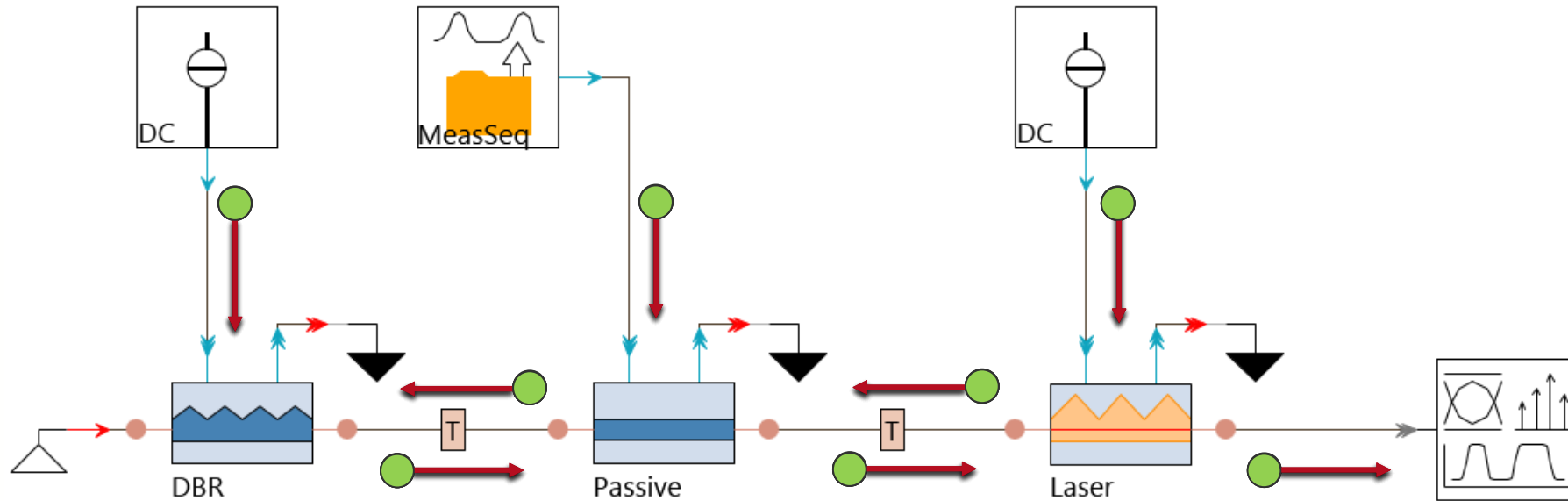


TLM for semiconductor lasers:

C. Arellano, S. Mingaleev, A. Novitsky, I. Koltchanov, and A. Richter, *Design of complex semiconductor integrated structures*, Proc. SPIE 7631 - Optoelectronic Materials and Devices IV, 76310K - 8 pages (2009).

Full dynamics of multisection semiconductor devices:

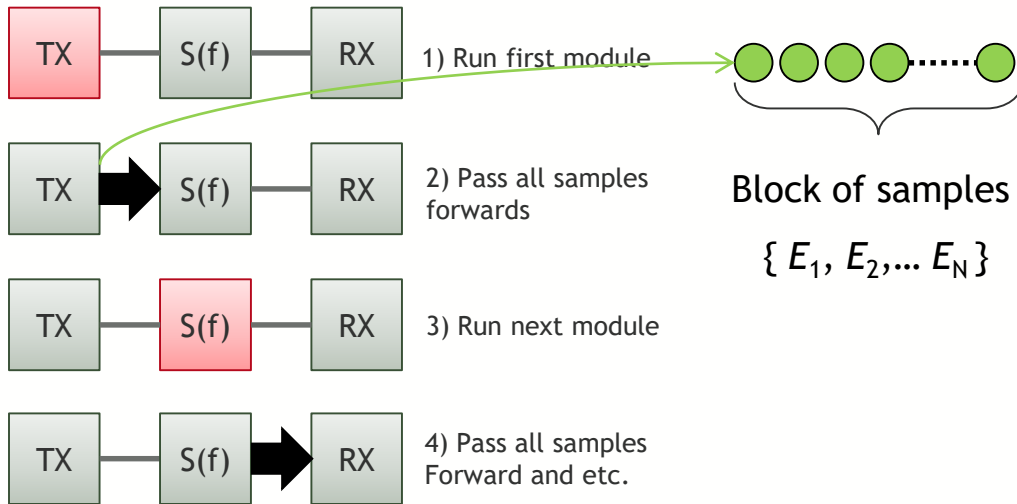
- nonlinearities during analog modulation
- roles of Kerr and two-photon absorption (TPA) nonlinearities
- evolution of lasing spectra during modulation
- CW spectral performance and purity (multimode, single-mode, noise floors)
- spectra during modulation (mode-hopping, dynamic chirp, instabilities)
- optical noise (intensity noise spectra, Amplified Spontaneous Emission)
- RF noise (Relative Intensity Noise, excess noise due to feedback, chaos)
- effects of external optical components, optical injection
- modulation responses (IM, FM, magnitude and phase)
- carriers and photons dynamics in lasers and amplifiers



How should interconnected components exchange data?

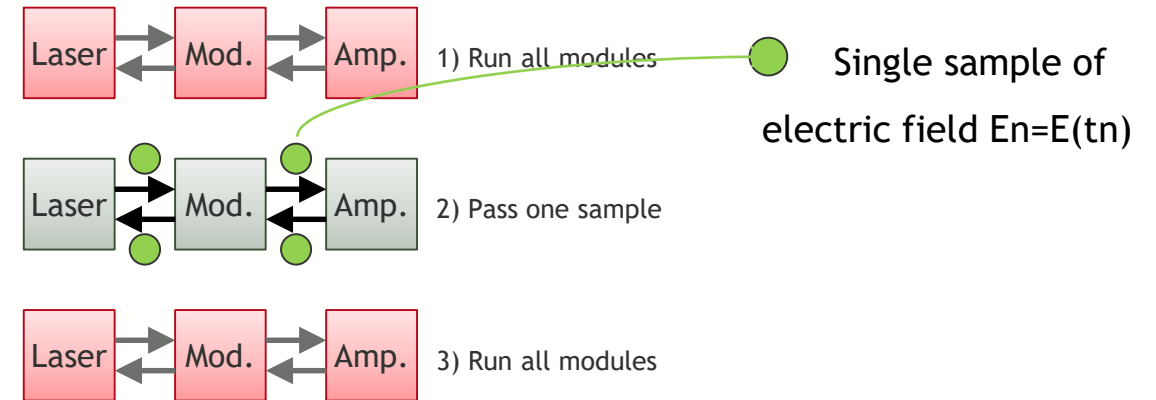
For active/dynamically tunable devices
time-domain sample-by-sample
 data exchange is required!

Block Mode & Frequency Domain



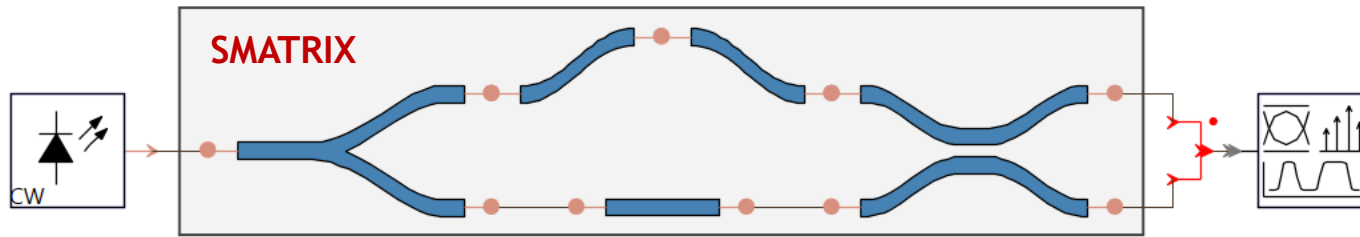
- Fast and efficient for the unidirectionally signal flow and passive, including large-scale, PICs.
- Elements could be described by S-matrices
- No nonlinear effects

Sample Mode & Time Domain



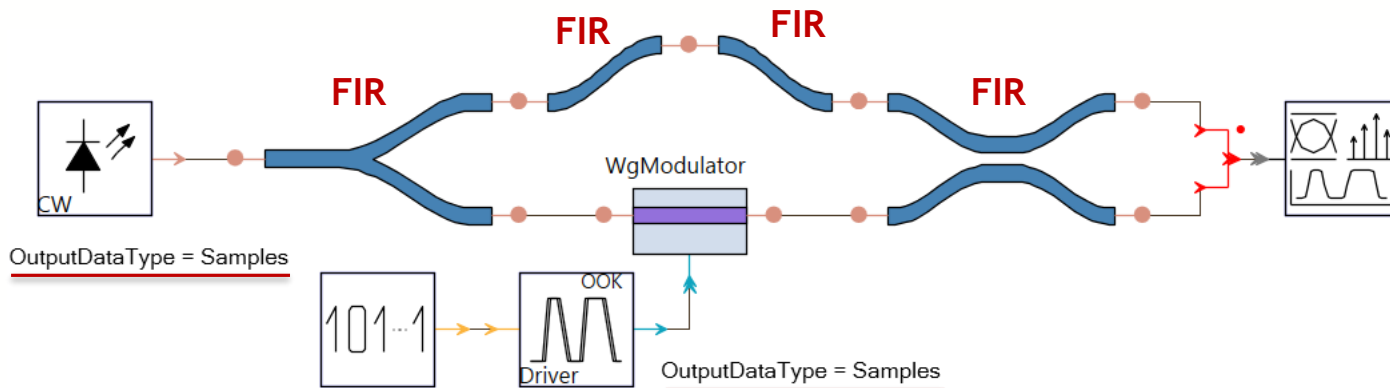
- Multi-section and external-cavity semiconductor lasers
- PICs with embedded active elements and/or dynamically-changing elements
- Time Consuming
- Inherently inaccurate

Circuits with Active Devices require Sample-Mode Simulations



OutputDataType = Blocks
BoundaryConditions = Periodic

Passive Circuits are best modeled
in frequency domain



OutputDataType = Samples

OutputDataType = Samples

Active Circuits require switching
to time-domain simulations, using
Sample-mode signals.

Simple solution: model each passive component in time-domain.

- How good is such an approach?
- How specifically are the passive devices modeled in this case?

Time-domain simulations for linear devices are most often based on either finite impulse response (FIR) digital filters:

$$A_{out}(t_i) = \sum_{m=0}^N a_m A_{in}(t_{i-m}) \quad \text{where} \quad t_i = i \cdot \Delta t$$

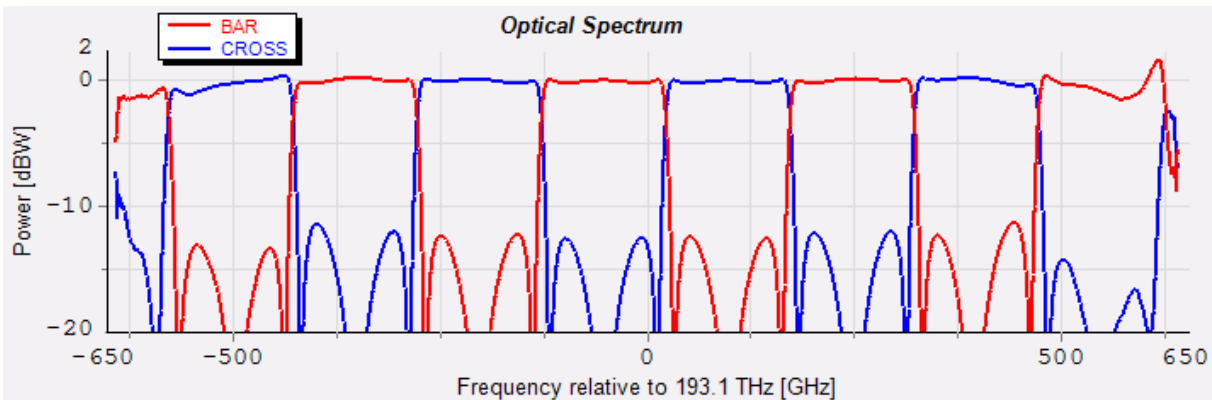
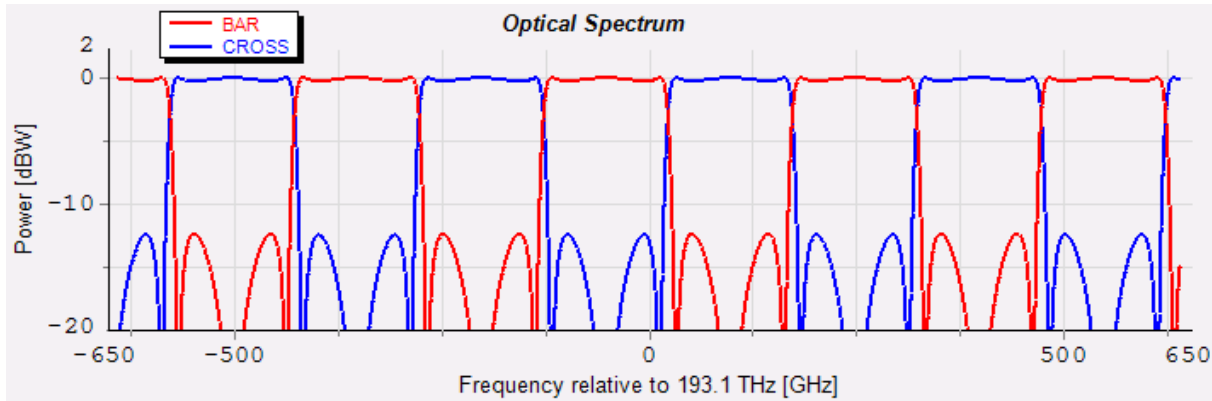
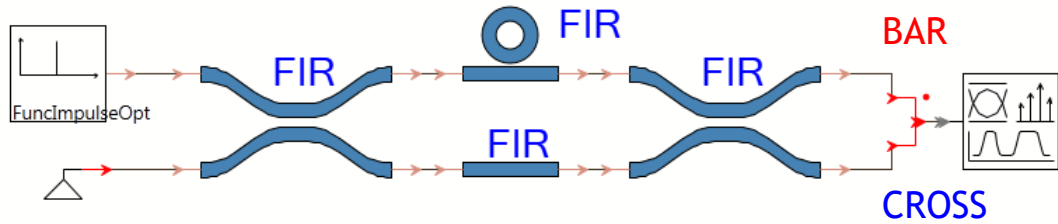
or infinite impulse response (IIR) digital filters:

$$A_{out}(t_i) = \sum_{m=0}^N a_m A_{in}(t_{i-m}) + \sum_{m=1}^M b_m A_{out}(t_{i-m})$$

However, even best designed digital filters are not fully accurate in a general case!

Classical problem - fractional delay filter, which delays a signal for a time period τ which is not equal to integer number of time steps Δt .

Time-Domain Approach for passive PIC sub-circuits



Frequency-
domain results

Pure time-
domain results

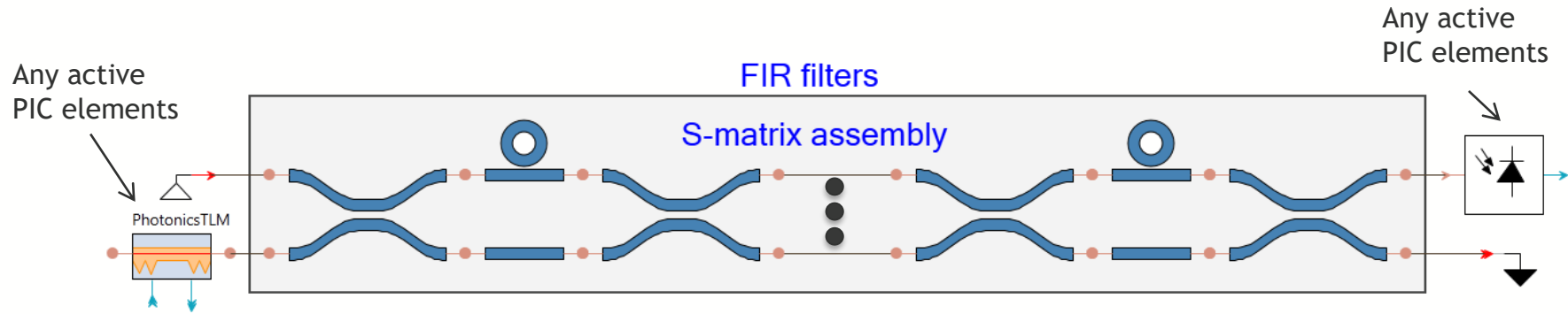
$$\begin{pmatrix} A_1^{out}(f) \\ A_2^{out}(f) \\ \dots \\ A_M^{out}(f) \end{pmatrix} = \hat{S}(f) \begin{pmatrix} A_1^{in}(f) \\ A_2^{in}(f) \\ \dots \\ A_N^{in}(f) \end{pmatrix}$$



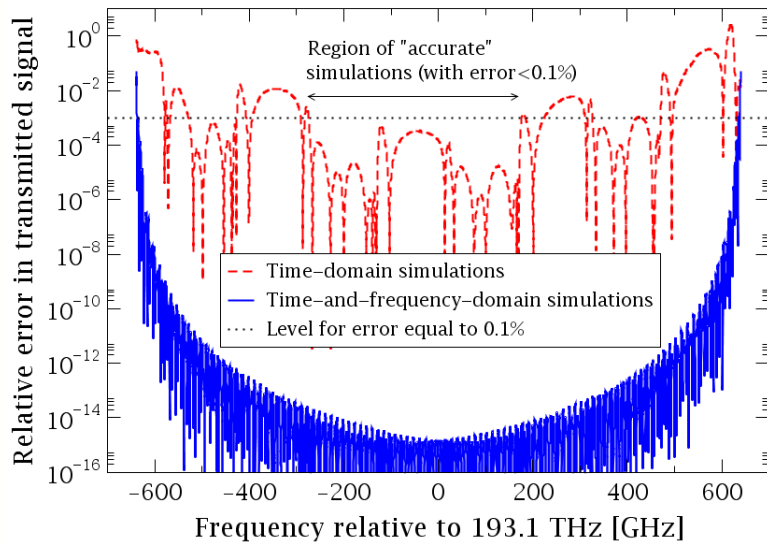
$$A_m^{out}(t_i) = \sum_{k=0}^{D_{mn}-1} S_{FIR,mn}(\tau_k) A_n^{in}(t_i - \tau_k)$$

- Time consuming
- The accuracy of FIR solution degrades in the edges of the simulated frequency band
- Errors are significant as the number of elements increases

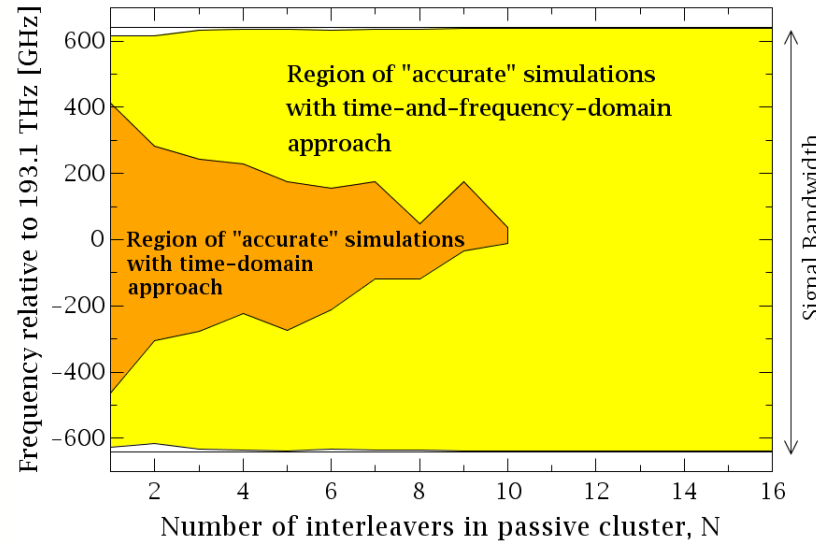
Hybrid Time-and-Frequency Domain a great way to scale up!



Optical error spectra after passing N=5 interleavers



Central frequency regions with errors below 0.1%



S. Mingaleev et al., *Hybrid time-and-frequency-domain approach for modeling photonic integrated circuits*, Proc. IEEE NUSOD, p. 183 (2011).

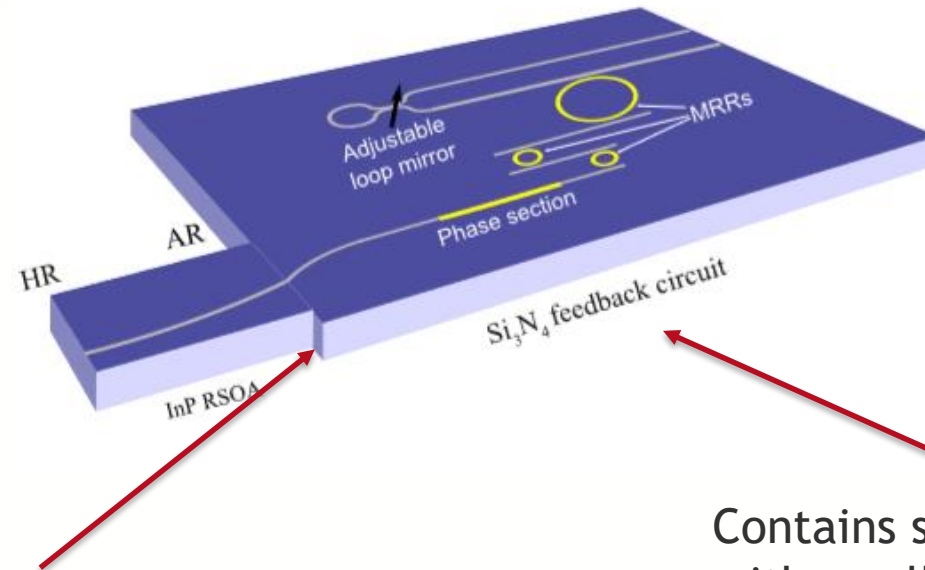
Hybrid Photonic Circuits Design Example Widely Tunable Laser Source

External cavity laser:

- InP gain section
- TriPleX tunable low loss mirror
- Hybrid assembly

Main design goals:

- Wide tunability (C-band)
- Low linewidth



Design example, based on:
Y. Fan, et al., "290 Hz intrinsic linewidth from an integrated optical chip-based widely tunable InP-Si3N4 hybrid laser", CLEO 2017, paper JTh5C.9.

Back reflections to laser \Rightarrow
changes to carrier density,
gain, effective index \Rightarrow
laser instabilities, noise

Contains small-size devices
with small group delays

Hybrid Time-and-Frequency domain is needed!

Hybrid Photonic Circuits Design Example

Widely Tunable Laser Source

External cavity laser:

- InP gain section
- TriPleX tunable low loss mirror
- Hybrid assembly

Main design goals:

- Wide tunability (C-band)
- Low linewidth

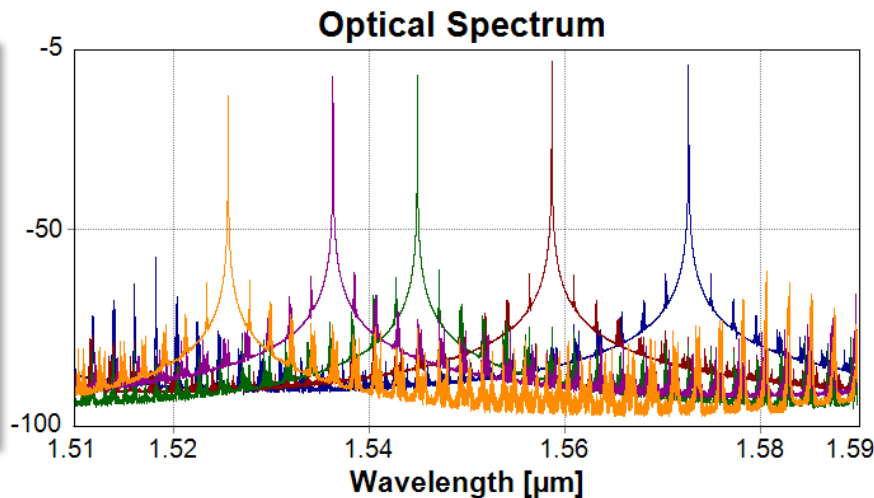
Very tricky to simulate directly!

$$\Delta f_{\text{LW}} < 100\text{kHz:}$$

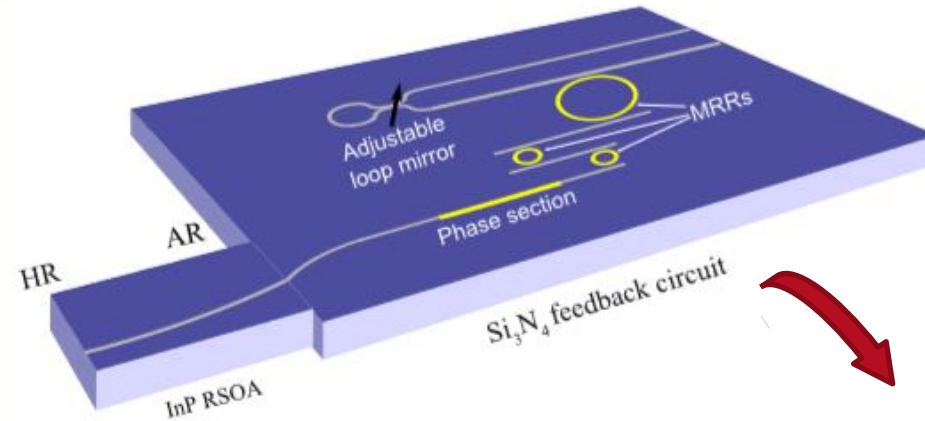
$$T_W > 4/\Delta f_{\text{LW}} = 40\mu\text{s}$$

$$f_s \approx 2.5\text{THz}$$

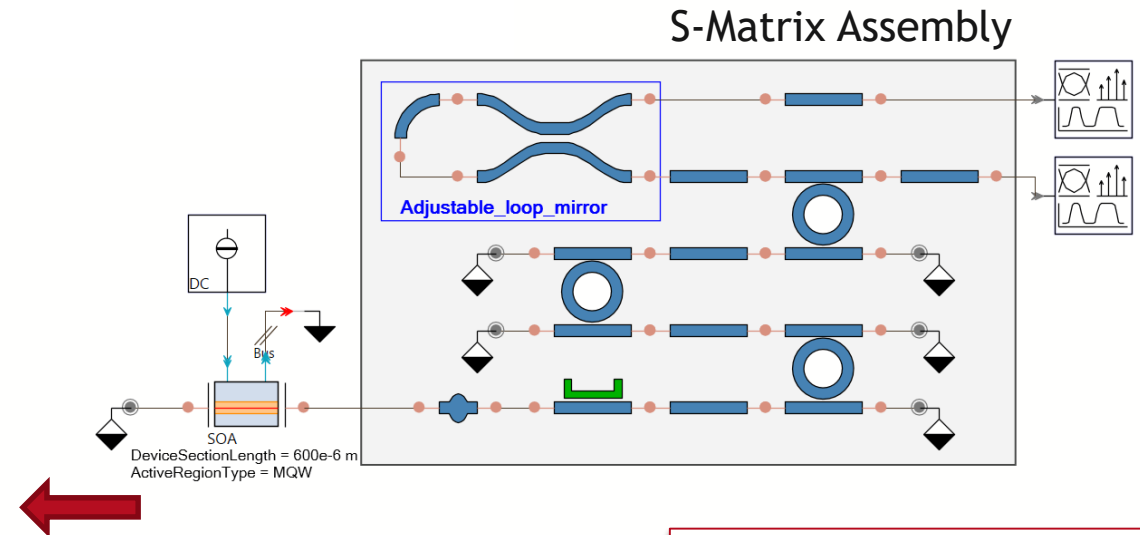
$$\Rightarrow \#_{\text{samples}} > 10^8$$



Simulated tuning characteristics



Design example, based on:
 Y. Fan, et al., "290 Hz intrinsic linewidth from an integrated optical chip-based widely tunable InP-Si3N4 hybrid laser", CLEO 2017, paper JTh5C.9.



Hybrid Photonic Circuits Design Example

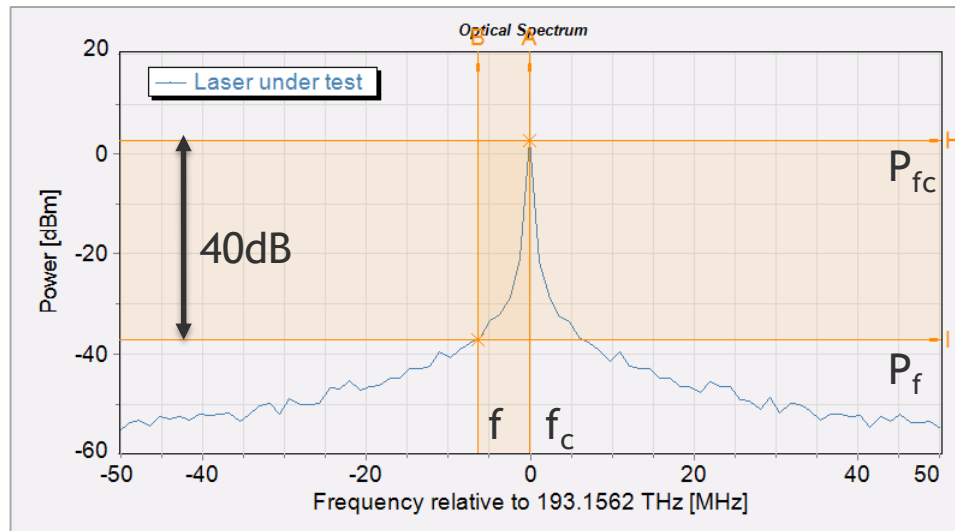
Indirect Estimation of Narrow Laser Linewidth

Spectral scaling (upper bound)

- Voigt shape fitting (assumes mix of Lorentzian & Gaussian spectral shape):

$$\Delta f_{lw} = 2(f_c - f) \sqrt{\frac{P_{fc}}{P_f}}$$

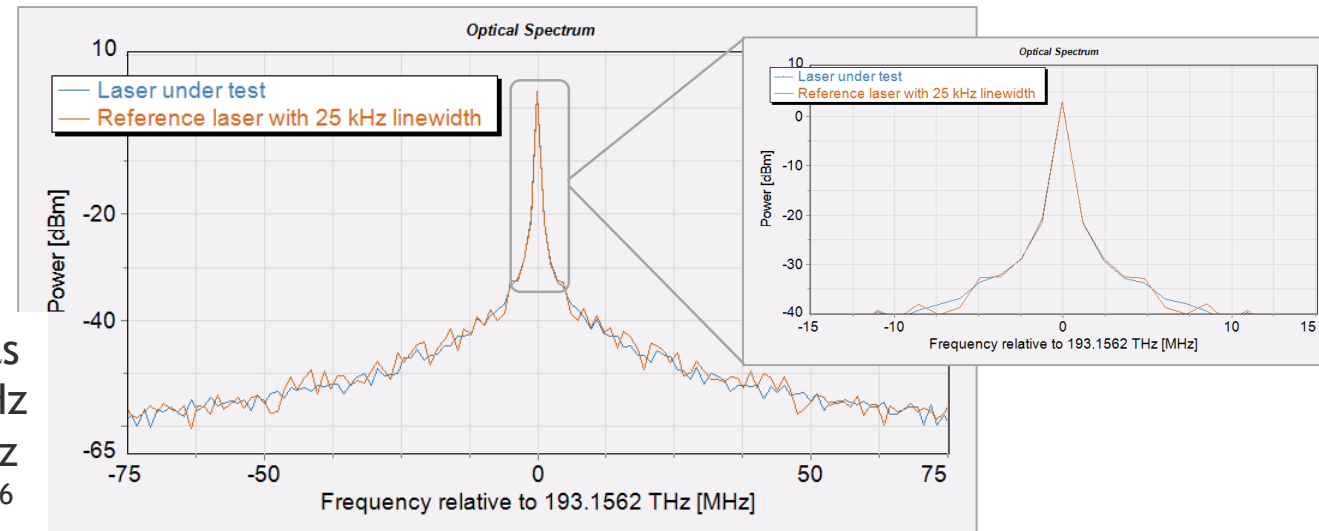
- Factor 200 (-40dB), factor 2000 (-60dB)
- Estimated linewidth: approx. 35kHz



$T_W \approx 0.8 \mu s$
 $\Delta f \approx 1.2 MHz$
 $f_s \approx 2.5 THz$
 $\#_{sa} \approx 2 \times 10^6$

Spectral fitting (more accurate)

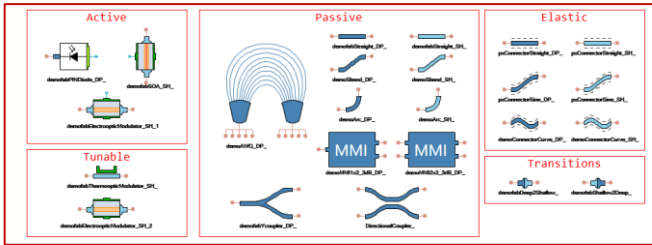
- Spectral shape fitting using reference laser with phase change modelled by random walk (Wiener process)
- Manually adjust parameters for linewidth and optical peak power
- Estimated linewidth: approx. 25kHz



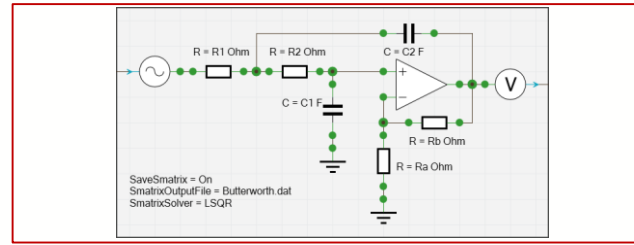
Layout-aware design approach and PDKs

- Introduction to Process Design Kits (PDKs)
- Layout-aware simulation
- Design Example: Integrated Optical Buffer

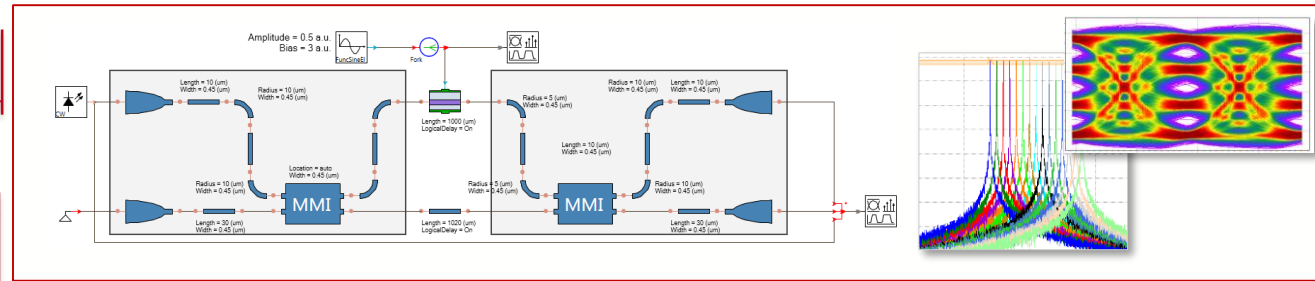
PDK Building Block Libraries



Electronic Design Automation



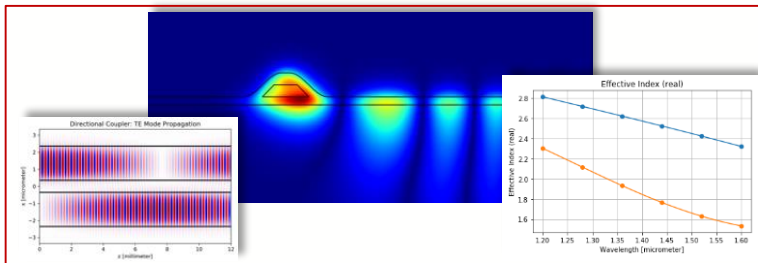
Photonic Circuit Simulation & System Validation



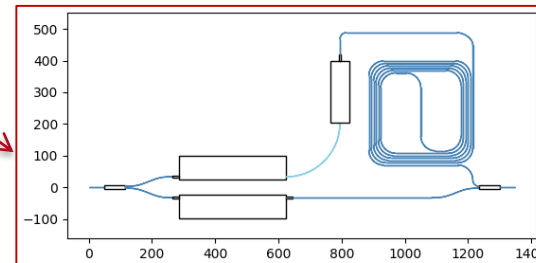
Optoelectronics and electrical simulation

Foundry-specific models
Extract device parameters

Device Modeling



Layout Design



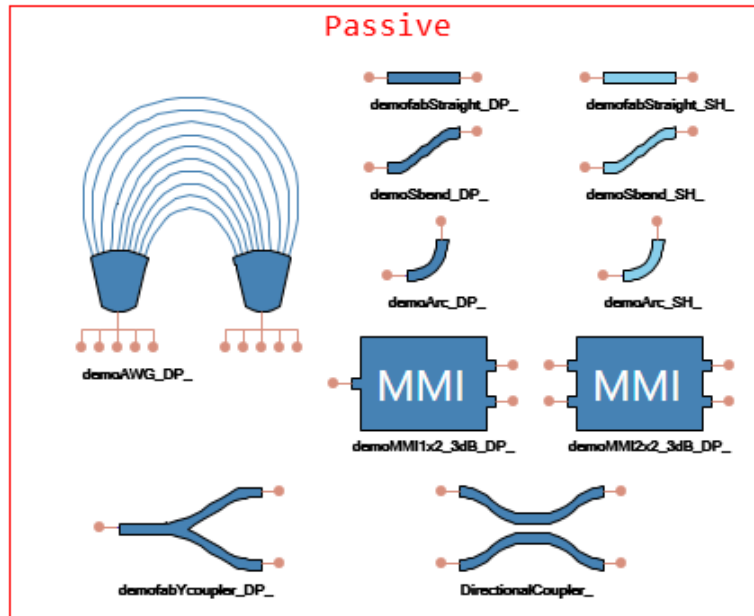
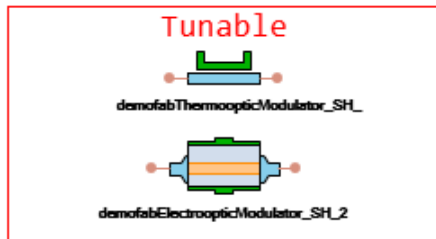
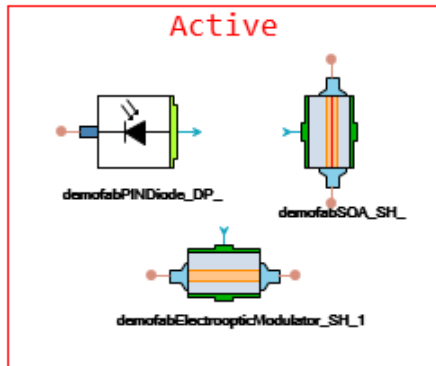
Layout design & DRCs,
verification of layout

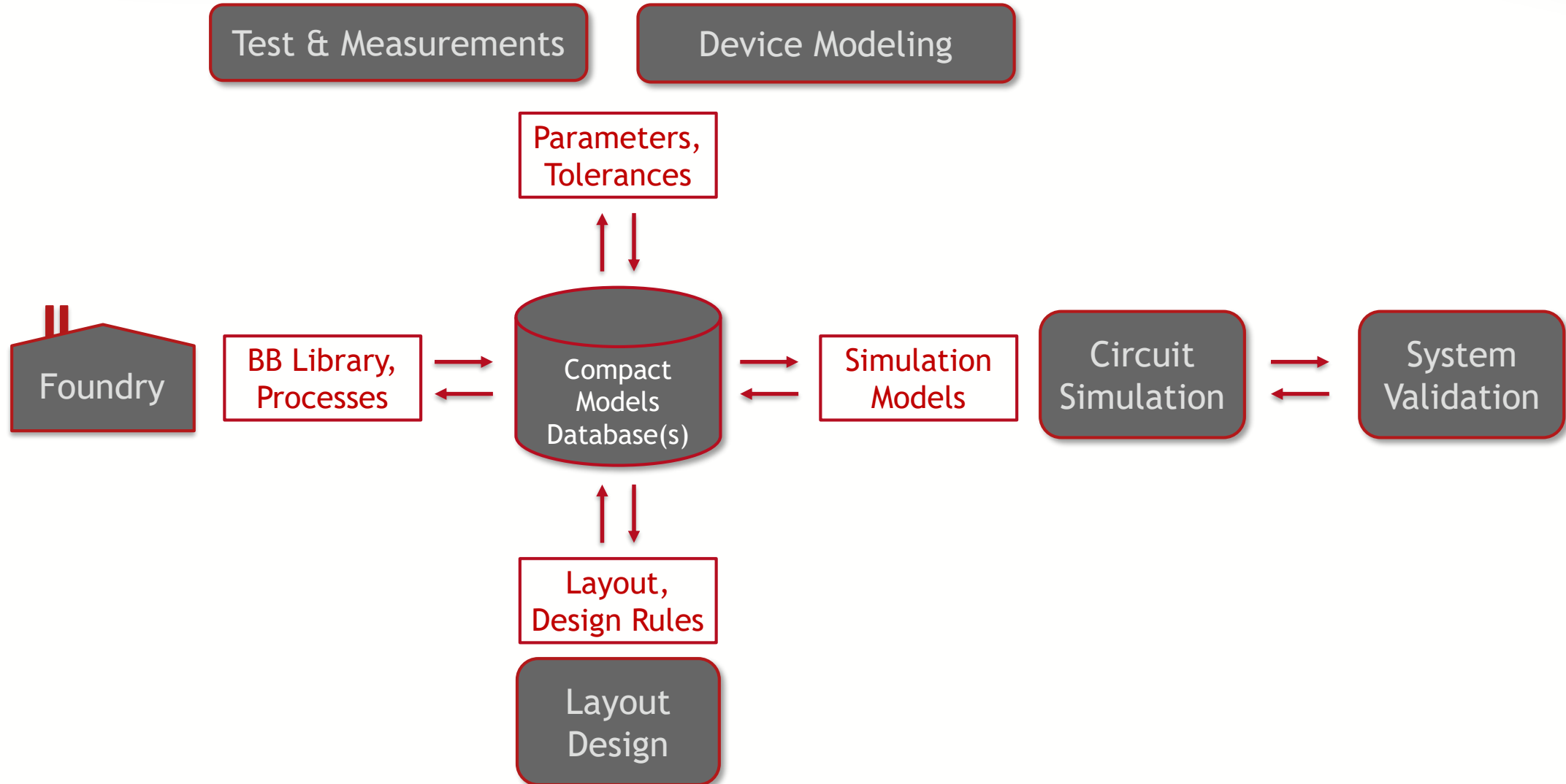
Foundry-Specific Process Design Kit (PDK):

- list of components
- corresponding certified compact models
- and geometric layout
- fabrication process info, design rules
- process variations



Design simplicity and predictability for the particular foundry

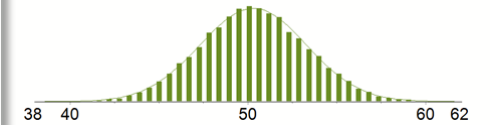
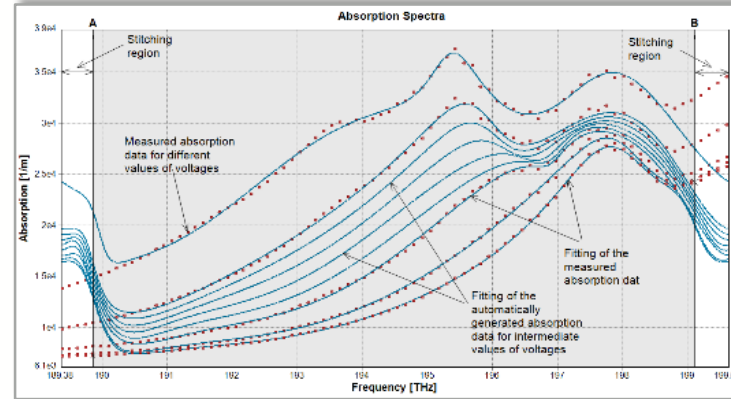
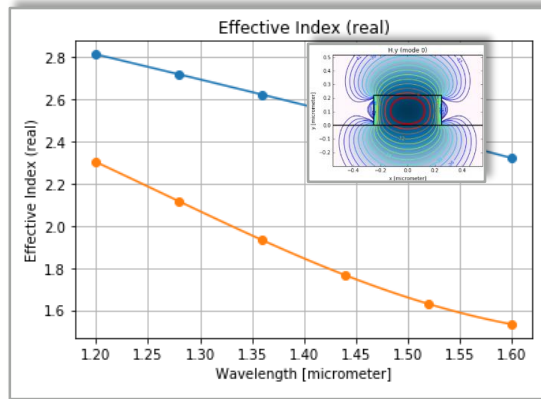




Built-in Modules


- Parameters
- Expressions
- Data Files
- Code

Measured and calculated parameters and their variations for analytical models



Measured and co-simulated models

```
// Comment line or lines, if required
# SMatrix MMI_M_N
# NumberOfInputPorts 5
# NumberOfOutputPorts 5
// Comment line or lines, if required
# InputPort left#1 TE
# OutputPort right#1 TE
# Frequency          Magnitude          Phase
# (Hz)              (dB)              (deg)
1.92100e+014        2.6938271e-001    -9.001622e+001
1.92110e+014        2.6970974e-001    -1.344023e+002
.....
1.94090e+014        2.7012581e-001    -8.927487e+003
1.94100e+014        2.6980897e-001    -8.927487e+003
// Comment line or lines, if required
```

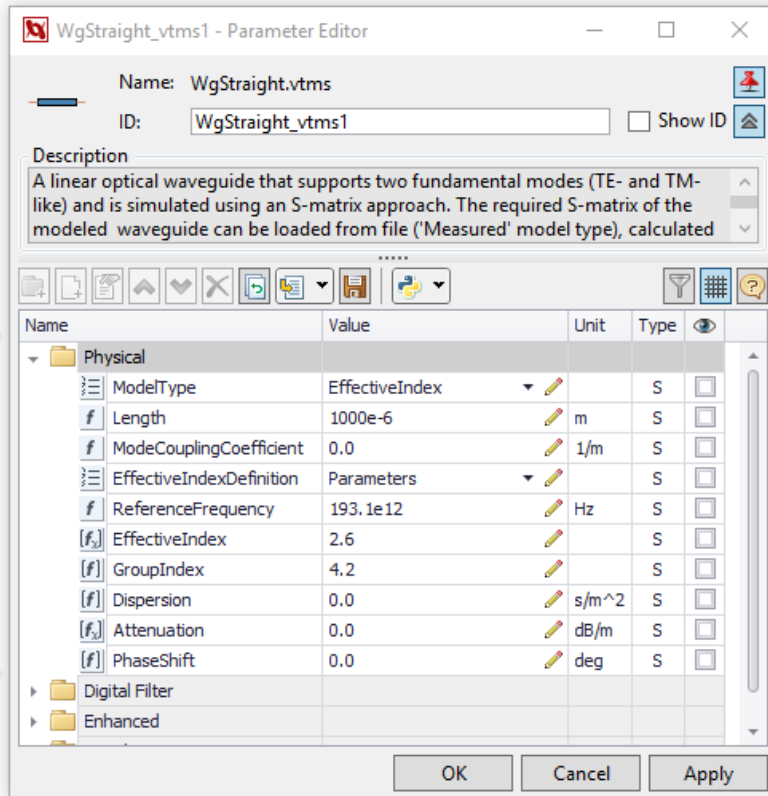


ModelType = Measured

```
class WgGrating(object):
    ...
    Waveguide Grating - 'BraggGrating' analytical model.
    ...
    def __init__(self, module_parameters):
        ...
        Method called during the module initialization.
        Inputs:
            module_parameters - dict of module parameters and their values.
        ...
        # create a list of all module states:
        self.states = GetParameters(module_parameters)
    ...
    #=====
    def transferf(self, port_out, port_in, mode_out, mode_in, f):
        ...
        # main S-matrix calculations (assuming
        sigma = self._mode[mode_in]
```



Build-in Module

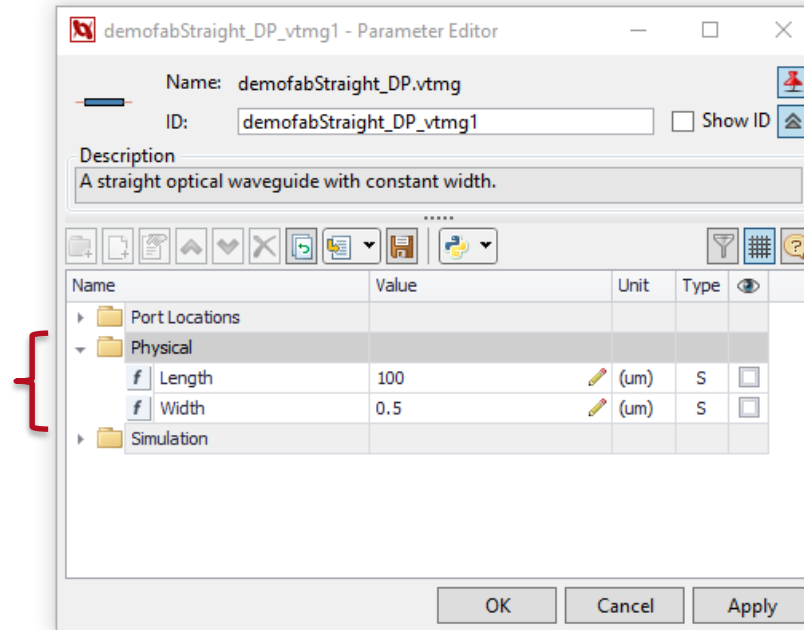



Name: WgStraight.vtms
ID: WgStraight_vtms1

Description: A linear optical waveguide that supports two fundamental modes (TE- and TM-like) and is simulated using an S-matrix approach. The required S-matrix of the modeled waveguide can be loaded from file ('Measured' model type), calculated

Name	Value	Unit	Type
Physical			
ModelType	EffectiveIndex		S
Length	1000e-6	m	S
ModeCouplingCoefficient	0.0	1/m	S
EffectiveIndexDefinition	Parameters		S
ReferenceFrequency	193.1e12	Hz	S
EffectiveIndex	2.6		S
GroupIndex	4.2		S
Dispersion	0.0	s/m ²	S
Attenuation	0.0	dB/m	S
PhaseShift	0.0	deg	S
Digital Filter			
Enhanced			

Demo PDK BB

Name: demofabStraight_DP.vtmg
ID: demofabStraight_DP_vtmg1

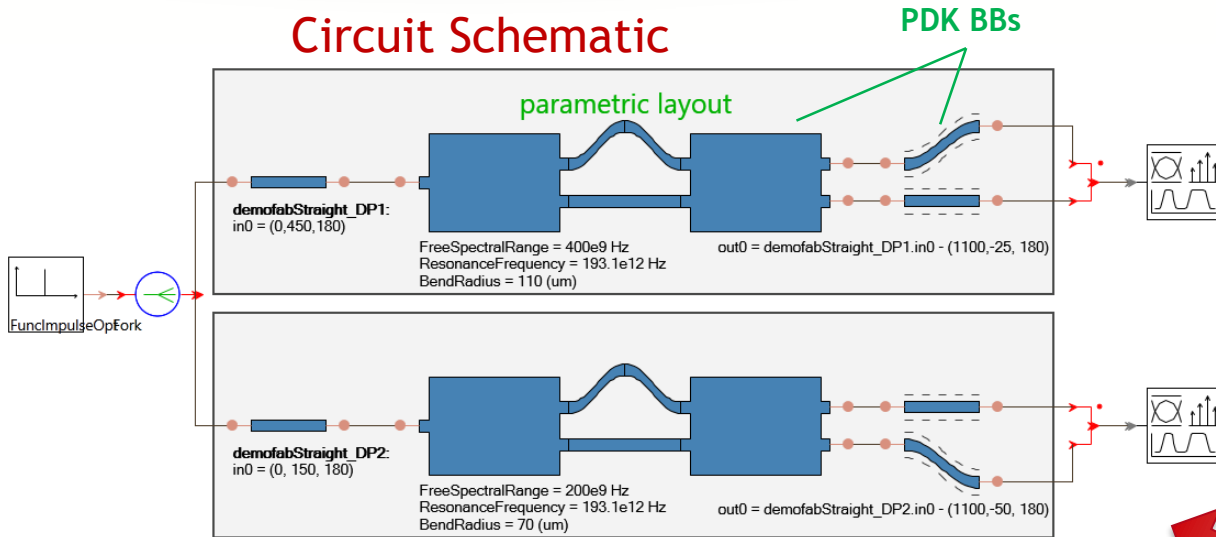
Description: A straight optical waveguide with constant width.

Name	Value	Unit	Type
Port Locations			
Physical			
Length	100	(um)	S
Width	0.5	(um)	S
Simulation			

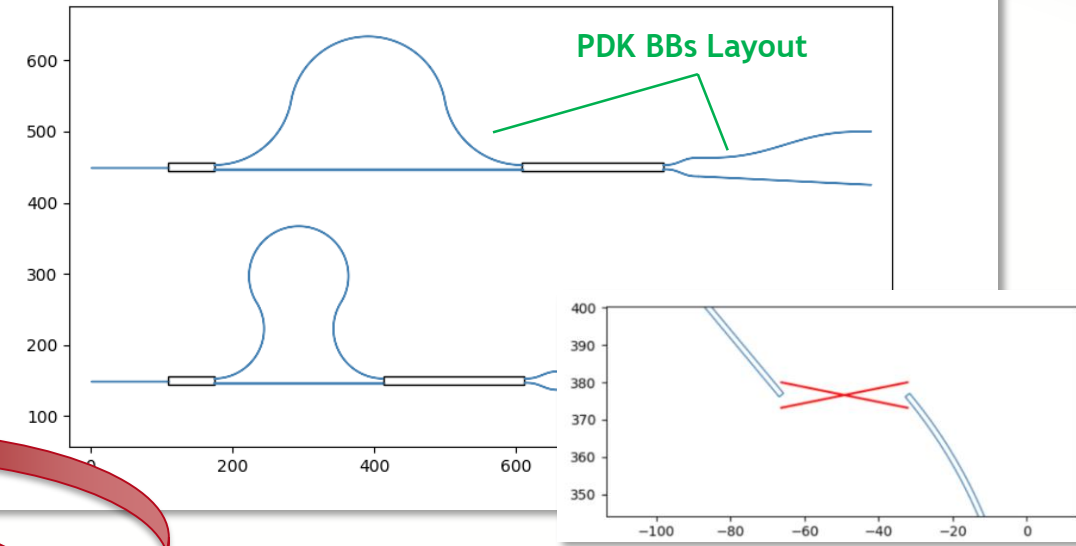
Using PDK Libraries

- Simplifies Design: only few variable parameters are available
- Certified operation
- Still having accurate, flexible models inside
- All features and domain are supported similarly to the build-in components
- Allows for automatic conversion into layout for subsequent mask generation and fabrication

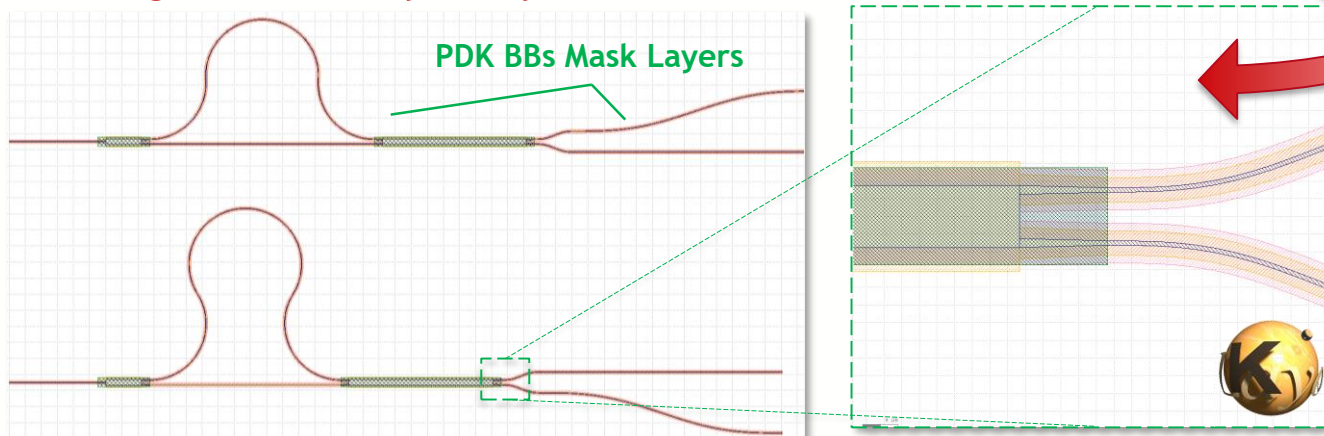
Circuit Schematic



Corresponding Top Layout View



Mask generated by a layout tool



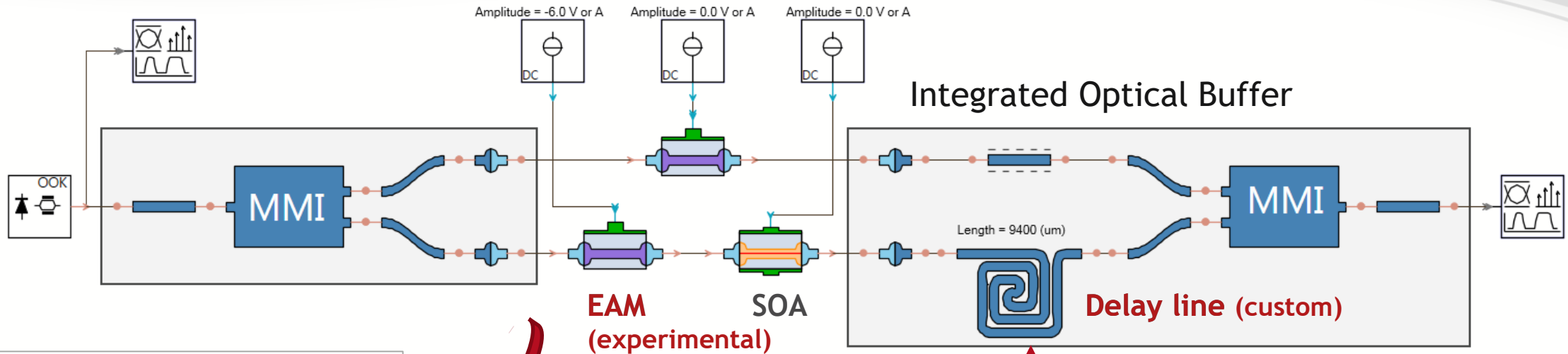
Circuit layout contains information:

- components connections,
- their positions,
- geometrical properties and
- corresponding process stages (mask layers)

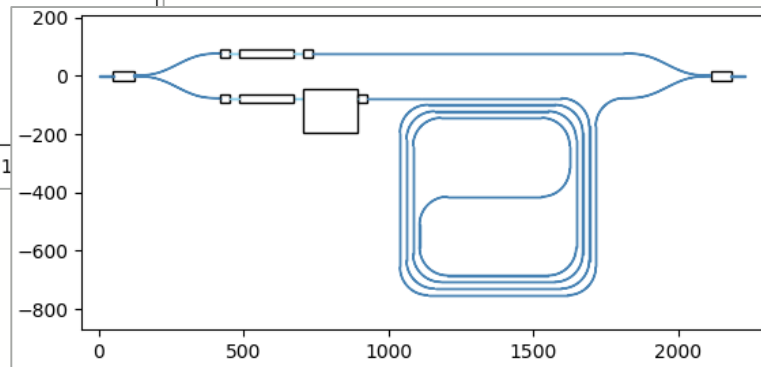
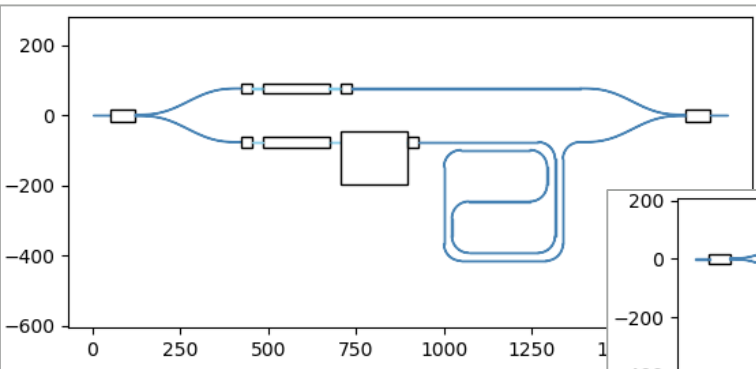
Design rule checking is important at this stage!

Design of Photonic Circuits using PDK

Custom and experimental BBs



Layout view



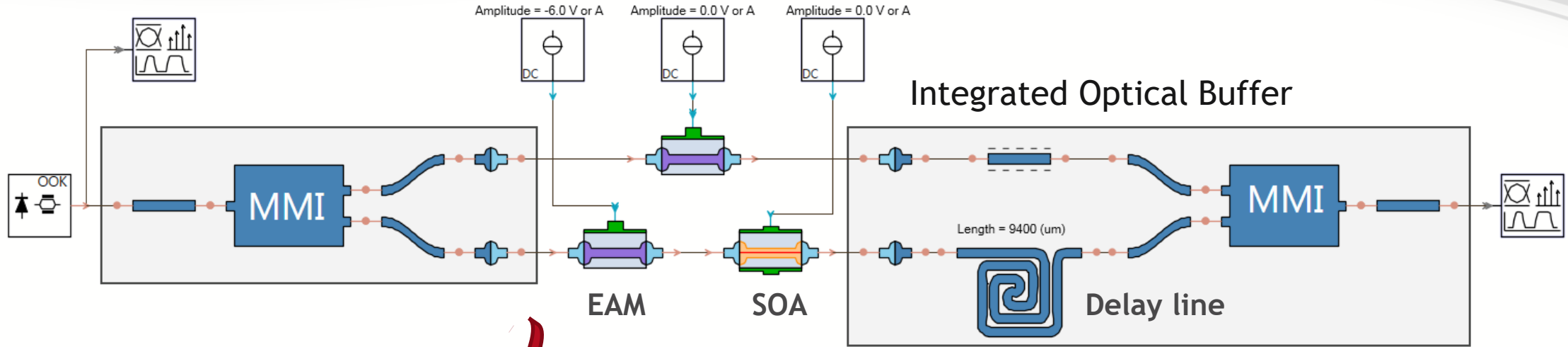
Experimental and custom BBs

- ✓ user-defined layout
- ✓ user-defined simulation model
- ✓ easily added by users



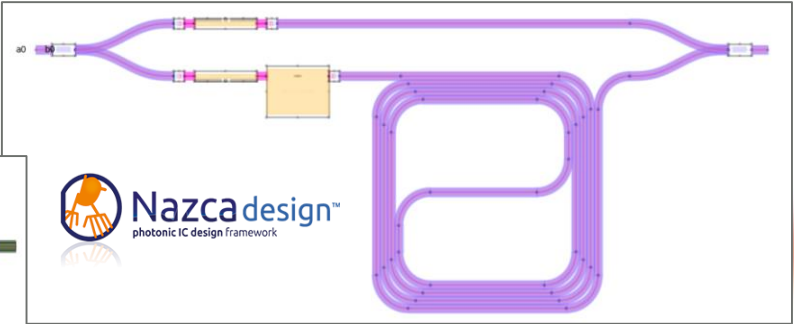
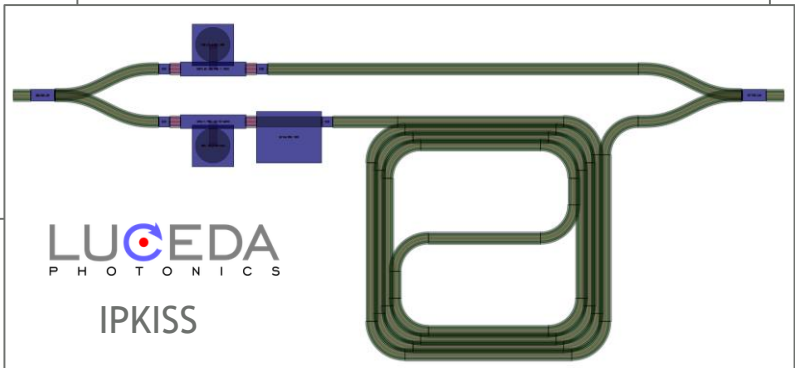
Based on photonics PDK supporting InP-foundry of SMART Photonics

Design of Photonic Circuits using PDKs DRCs and GDS mask generation



Automated export to 3rd party layout tool for DRC and GDS mask

SYNOPSYS
OptoDesigner



Based on photonics PDK supporting InP-foundry of SMART Photonics

Why Should be Aware of Circuit Layout?

Standard schematic-driven approach

- BB layout determined by its parameters (length, bend angle, etc.)
- ⇒ IC layout fully determined by connectivity between BBs
- ⇒ Allows immediate IC simulation as BB model is known at each design step

BB - Building Block
IC - Integrated Circuit

Two roles of optical waveguides

- Could act as connecting device: routes optical signals between building blocks of the circuit
- ⇒ Detailed properties (length, width, shape) are not critical, may be ignored
- Could act as functional device: determine interference between signals traveling in different paths
- ⇒ Detailed properties are very important, already at the beginning of circuit design

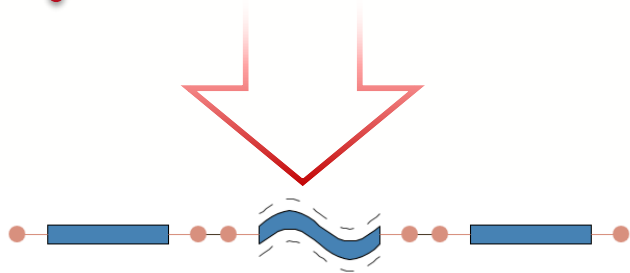
Problem: Often, no clear separation possible!

Photonic IC design \neq circuit design + layout design
⇒ **Tight interaction between layout and circuit design necessary**

How to connect arbitrary oriented components on the layout?



Dedicated “elastic” elements introduces, which automatically adapted to best fit layout



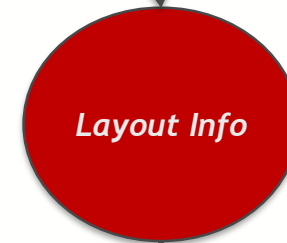
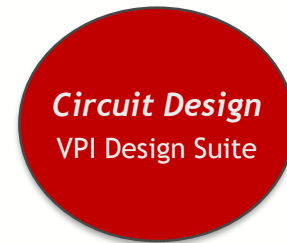
Name	Value	Unit	Type	Eye
Port Locations				
A in0	auto		S	<input type="checkbox"/>
A out0	auto		S	<input type="checkbox"/>
Physical				

- Corresponding circuit representation usually has no geometrical parameters
- At least some BBs require specification of the ports locations in the circuit simulator

How could circuit with adaptive layout elements be simulated?

Create complete circuit design including elastic connectors

Use layout information to “resolve” it: find port locations and directions for all elastic connectors



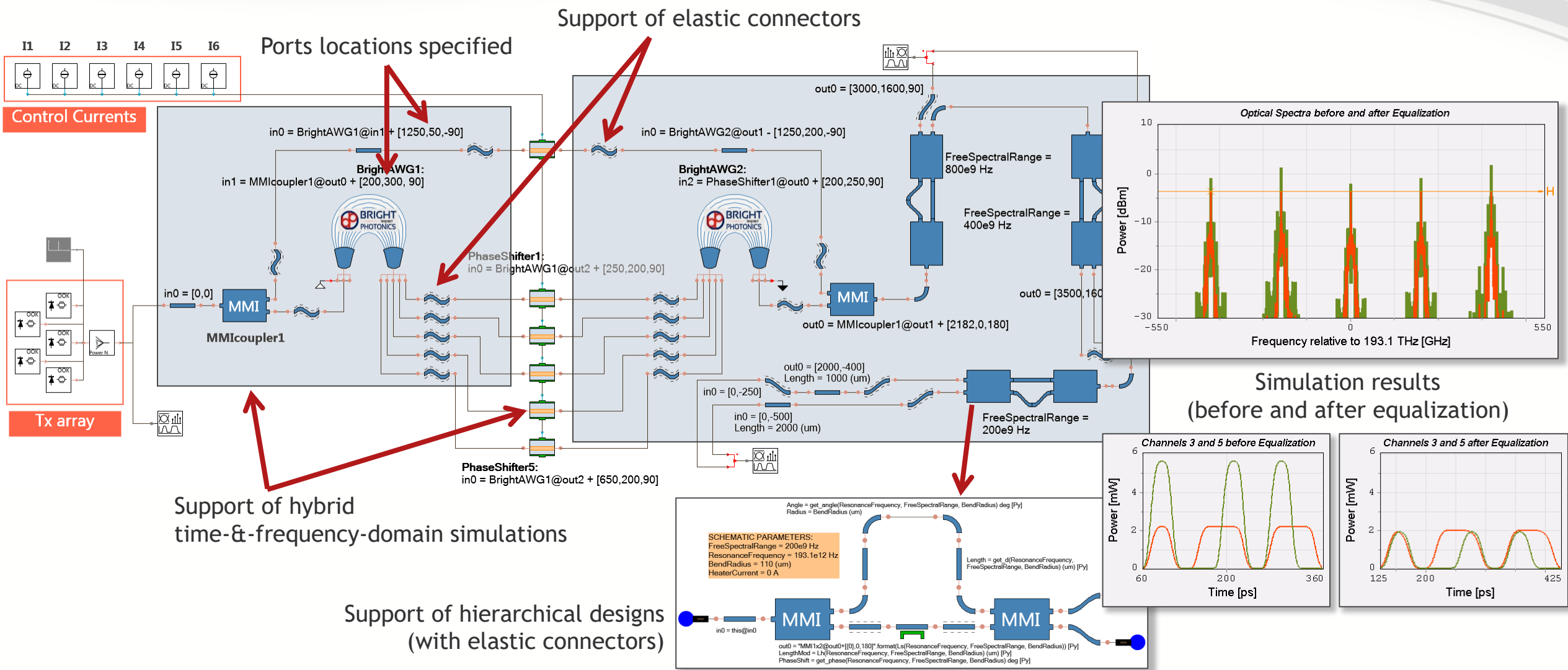
Convert port locations and directions for elastic connectors into waveguide lengths required by simulation models

Runs silently in the background, no manual user action needed!

Create simulation models for elastic connectors, run simulation for the whole circuit

Layout-Aware Schematic-Driven Design Flow

Dynamic WDM Channel Equalizer



Design automation techniques

- Design Example: 2D Beam Scanner for LIDAR
- Simulating arrays and chains of modules
- Scripting for schematic capture
- Design Example: High-Order Ring-Based Optical Filter
- Optimization and automated parameters settings
- Design robustness & sensitivity

Hybrid III-V / Silicon Design Example

2D Beam Scanner for LIDAR

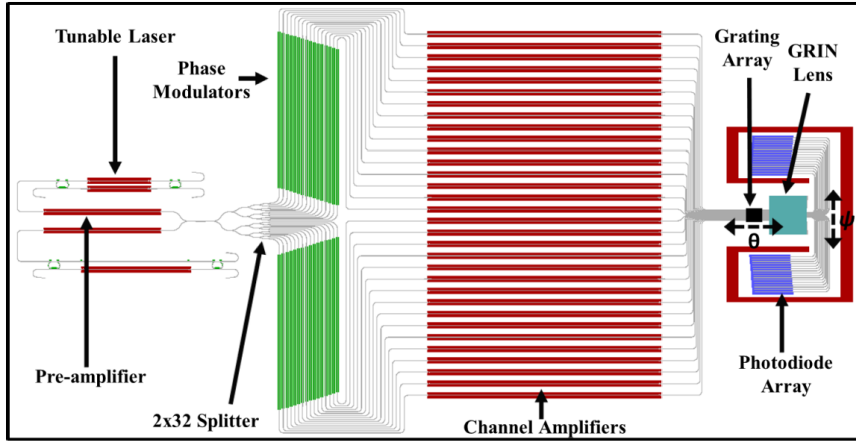
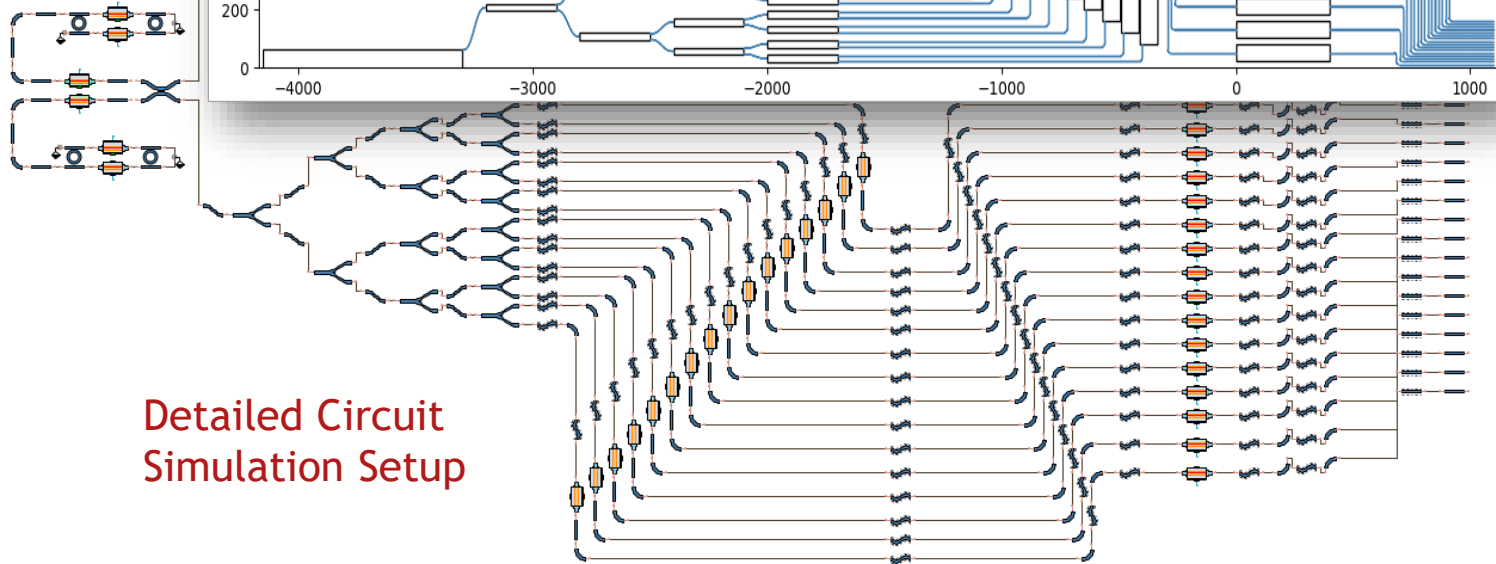
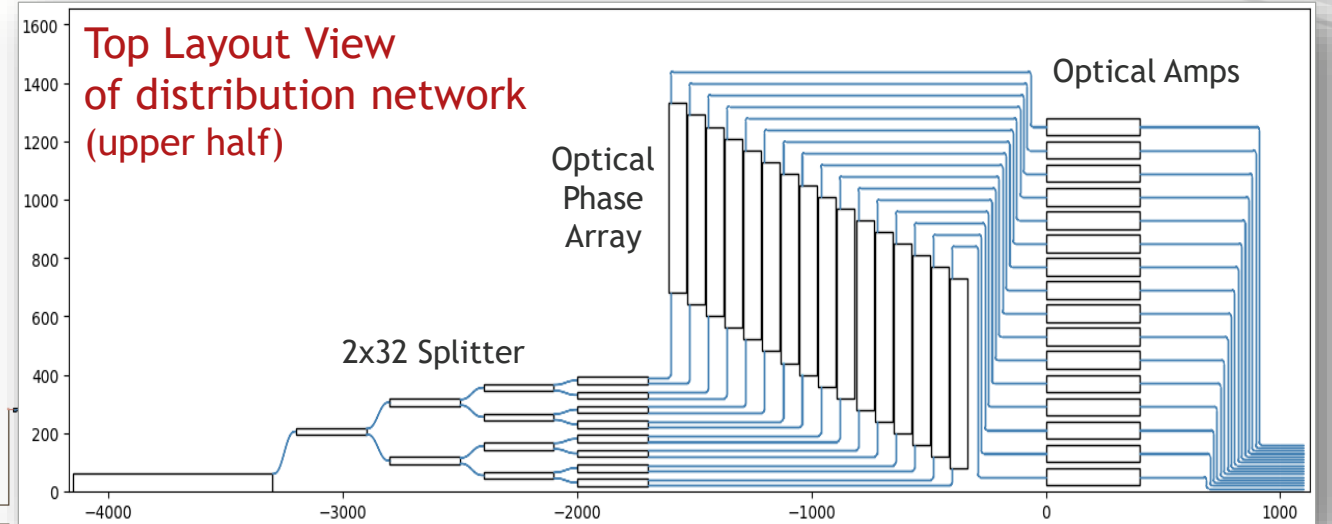
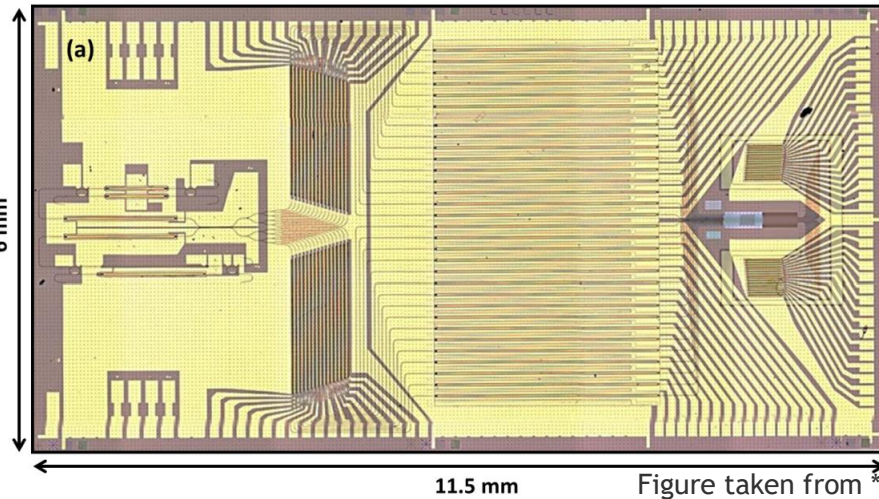


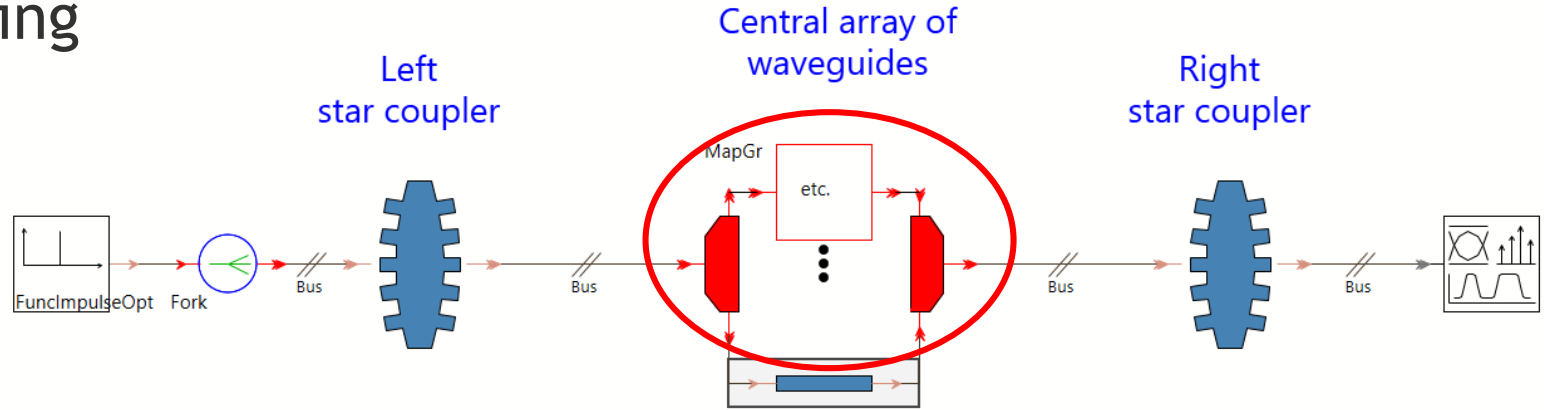
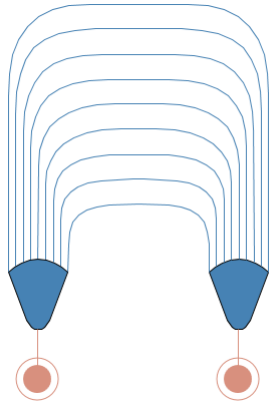
Figure taken from *



Design example, based on works performed by University of California Santa Barbara:

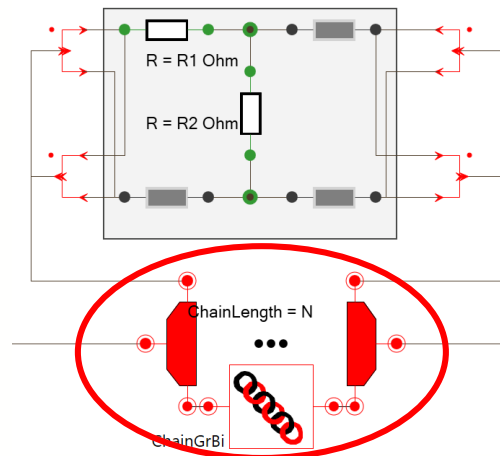
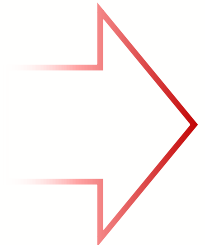
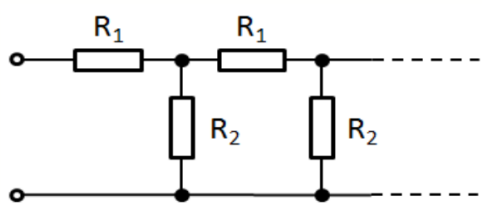
* J.C. Hulme et al., Fully integrated hybrid silicon two dimensional beam scanner, Opt. Express 23, 5861-5874 (Feb 2015).

Arrayed Waveguide Grating



Length = !" expr {WgMinimumLength}+({WgNumber}-{NumberOfWaveguides}/2)*({LengthIncrement}+(0.5-({WgNumber}%2))*{IncrementDifference})" m
 PhaseShift = !" expr {PhaseShiftVariation}* (0.5-rand())" deg

Infinite Resistor Series

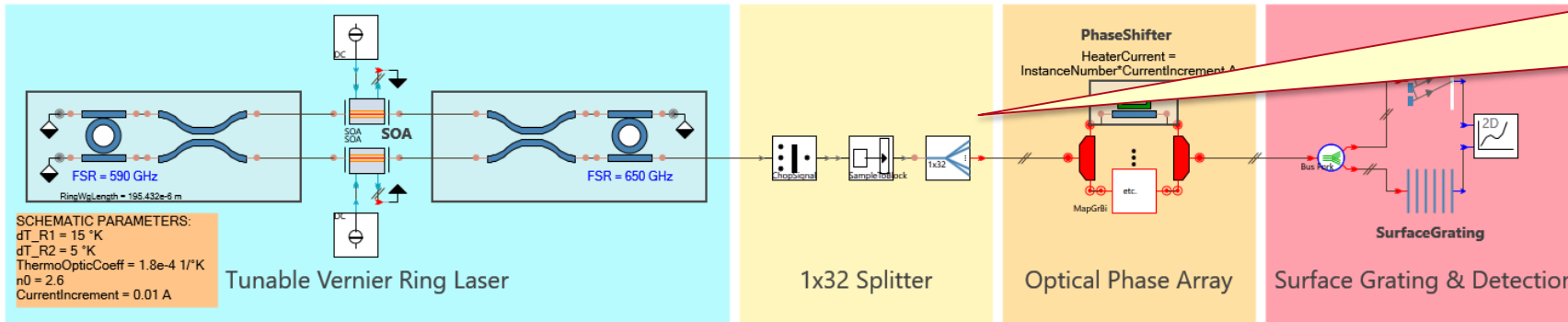


- Graphical solution: higher-order function modules repeat connected blocks the specified number of times
- Parameter expressions could be used to set the parameters for each instance to different values

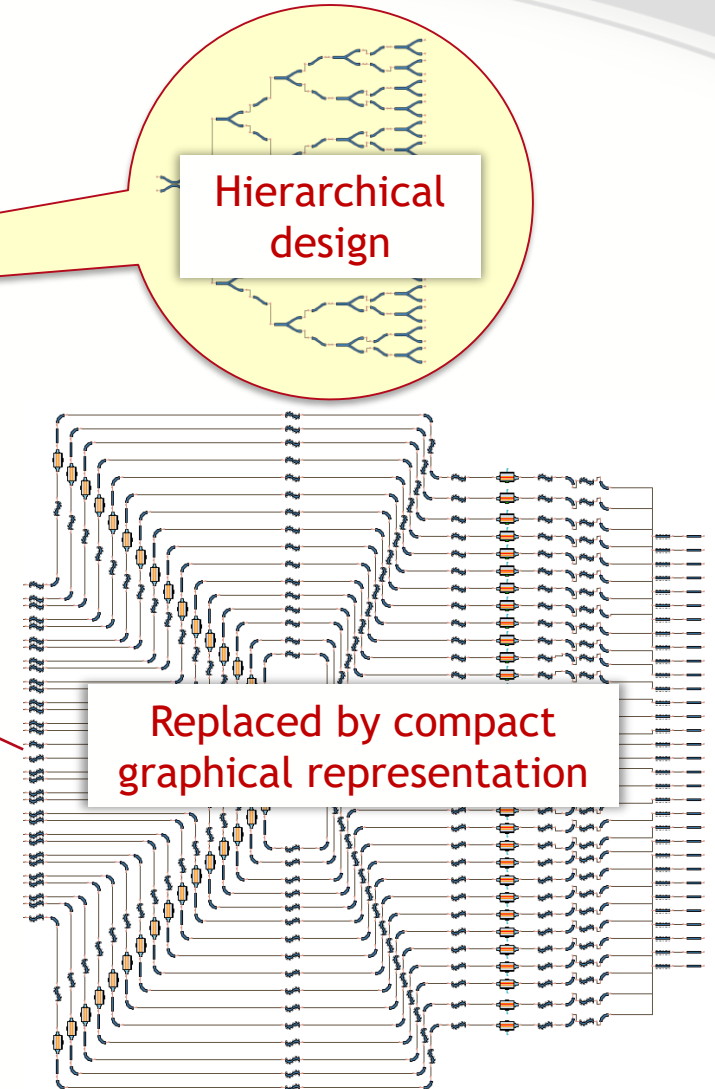
Hybrid III-V / Silicon Design Example

2D Beam Scanner for LIDAR

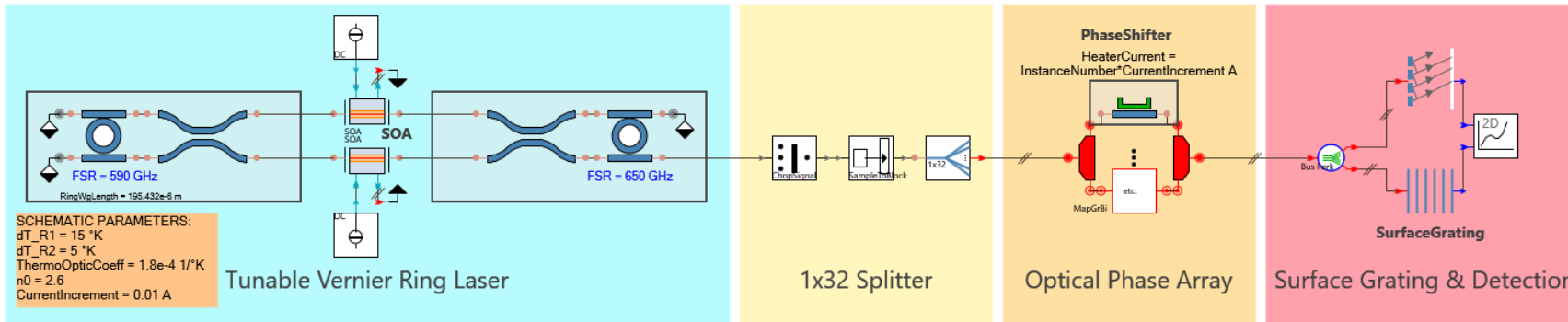
Simulation Setup for Testing the Scanning Performance



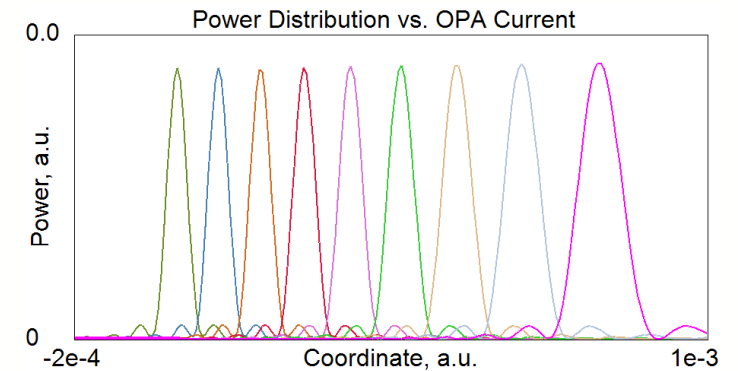
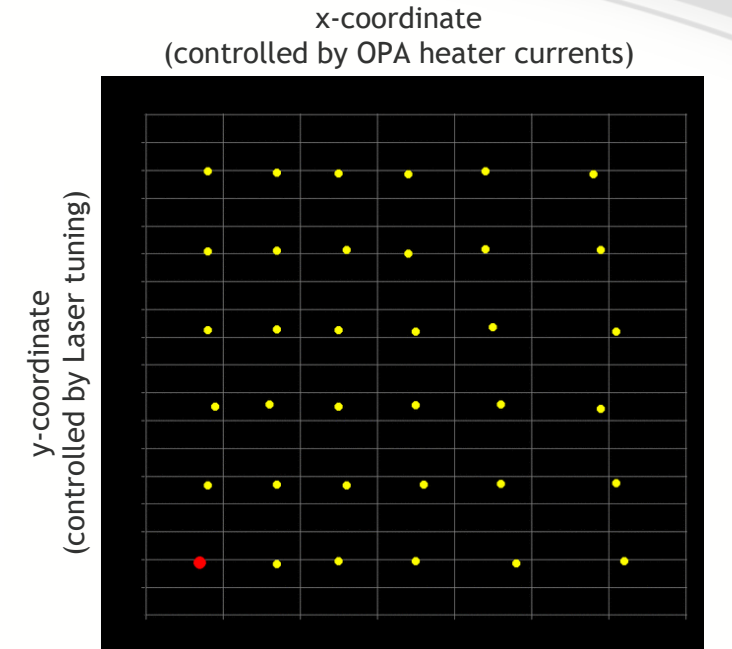
- ✓ Hybrid **time-and-frequency domain modeling** for accurate simulation of tunable laser characteristics
- ✓ **Hierarchical designs** to easily manage system complexity (1x32 splitter)
- ✓ **Graphical** solution to concisely represent serial or **parallel structures** (phase shifter array)
- ✓ **Python cosimulation** to address custom components or technologies (beam propagation and projection)

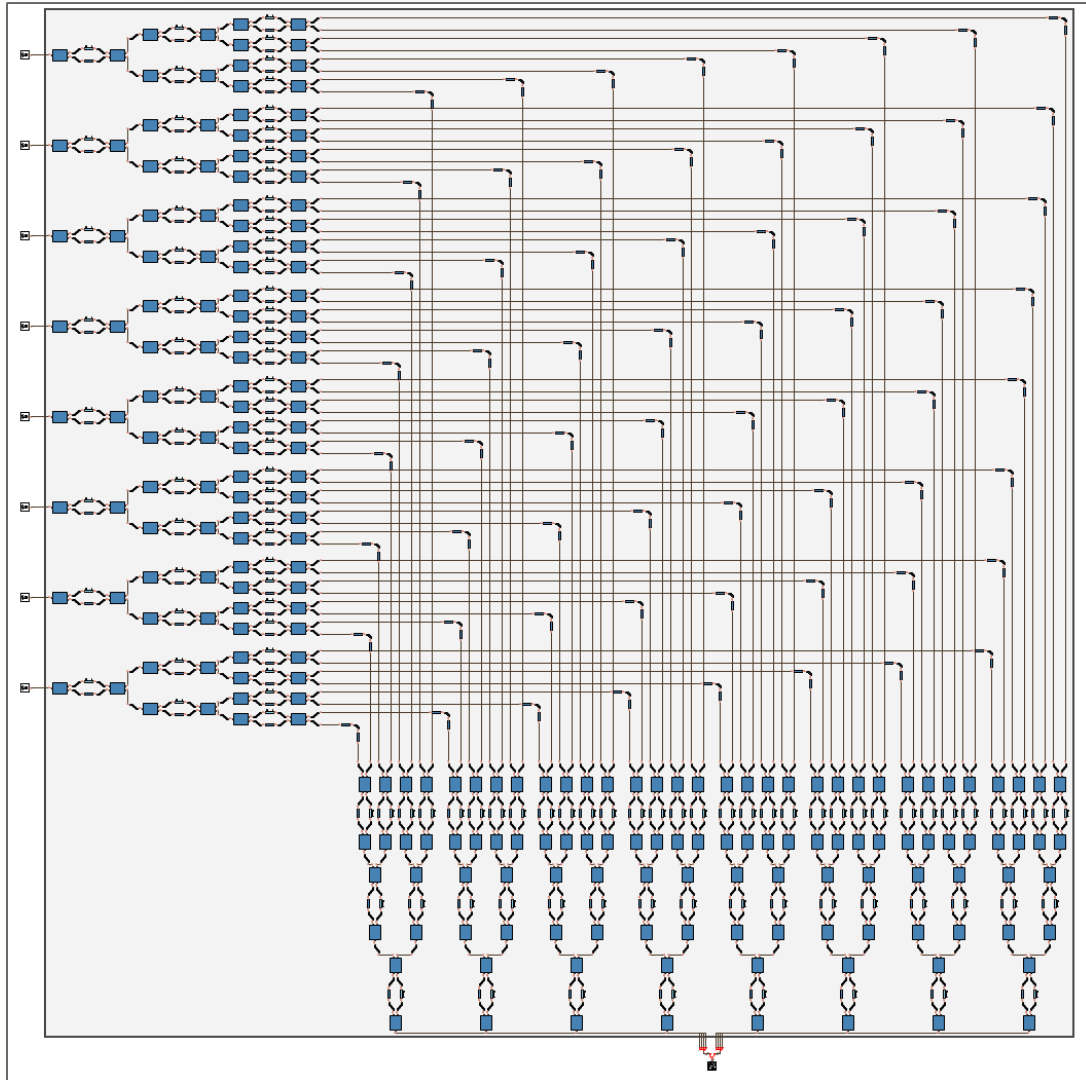


Simulation Setup for Testing the Scanning Performance



- ✓ Hybrid **time-and-frequency domain modeling** for accurate simulation of tunable laser characteristics
- ✓ **Hierarchical designs** to easily manage system complexity (1x32 splitter)
- ✓ **Graphical** solution to concisely represent serial or **parallel structures** (phase shifter array)
- ✓ **Python cosimulation** to address custom components or technologies (beam propagation and projection)





Python script for creation of an NxN optical switch

```
def create(self):
    id = self.id
    x = self.x
    y = self.y
    xx = self.xx
    yy = self.yy
    phase = self.phase
    L = self.L
    w = self.w

    L_to = L
    L_wg = L+100.0
    L_sb = 20.0
    H_sb = 15.0

    mmilx2_id = id + "_mmilx2"
    pde.star(mmilx2_id, "URN:TKIT_LIB::PDK DFO Modules\Passive\demoMMI1x2_3dB_DP.vtmg:")
    pde.setpos(mmilx2_id, x+5, y)
    if self.fixed:
        pde.setstate(mmilx2_id, "in0", '{{{0},{1}}}'.format(xx,yy))

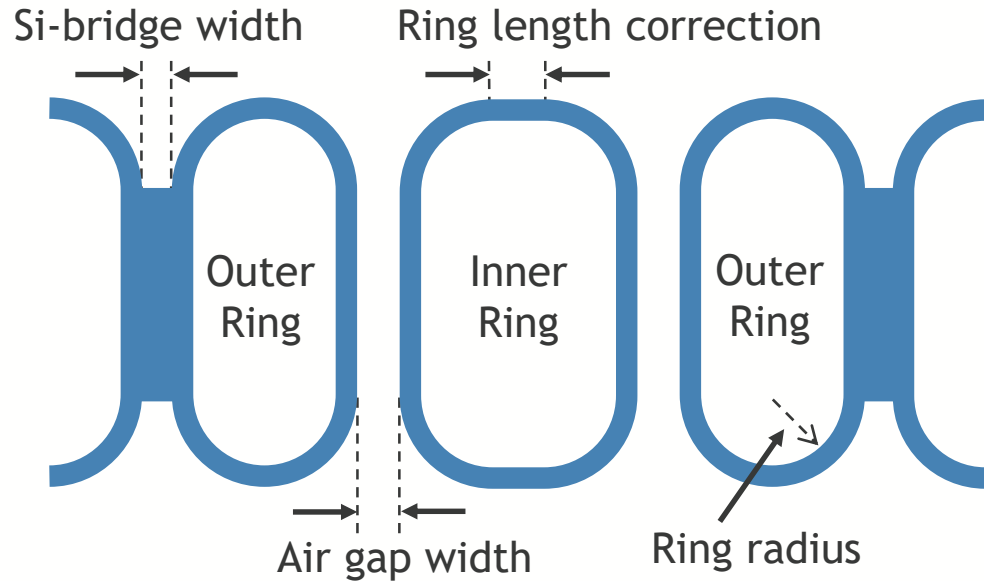
    mmi2x2_id = id + "_mmi2x2"
    pde.star(mmi2x2_id, "URN:TKIT_LIB::PDK DFO Modules\Passive\demoMMI2x2_3dB_DP.vtmg:")
    pde.setpos(mmi2x2_id, x+33, y)

    to_id = id + "_to"
    pde.star(to_id, "URN:TKIT_LIB::PDK DFO Modules\Tunable\demofabThermoOpticModulator_SH.vtmg:")
    pde.setpos(to_id, x+19, y-3)
    pde.setstate(to_id, "LengthMod", L_to)
    pde.setstate(to_id, "WidthWaveguide", w)
    pde.setstate(to_id, "PhaseShift", phase, show=False)

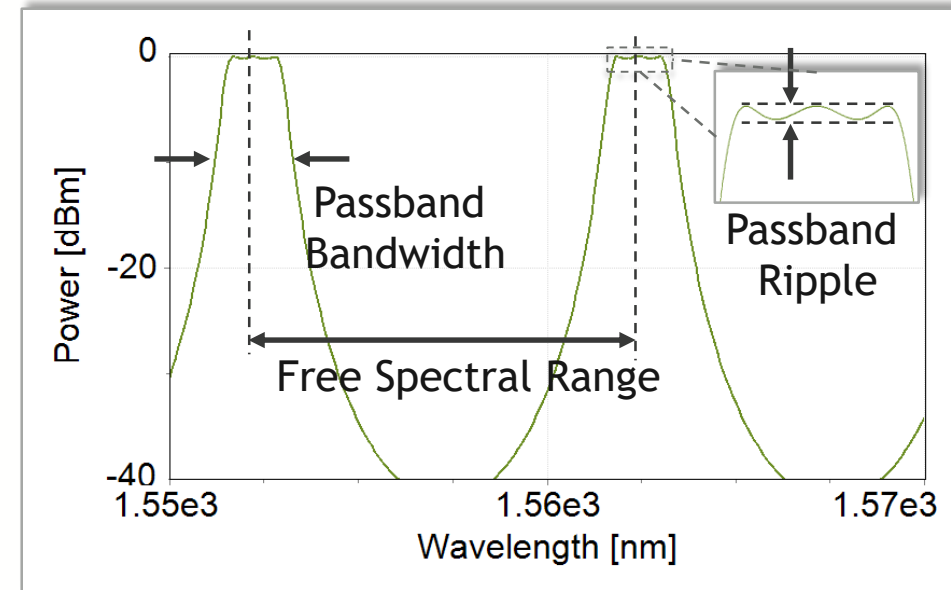
    wg_id = id + "_wg"
    pde.star(wg_id, "URN:TKIT_LIB::PDK DFO Modules\Passive\demofabStraight_DP.vtmg:")
    pde.setpos(wg_id, x+19, y+3)
    pde.setstate(wg_id, "Length", L_wg)
    pde.setstate(wg_id, "Width", w)
    #pde.setstate(wg_id, "PhaseShift", '90')

    sb1_id = id + "_sb1"
    pde.star(sb1_id, "URN:TKIT_LIB::PDK DFO Modules\Passive\demoSB1.vtmg:")
    pde.setpos(sb1_id, x+13, y-2)
    pde.setstate(sb1_id, "Length", L_sb)
    pde.setstate(sb1_id, "Height", H_sb)
    pde.setstate(sb1_id, "Width", w)
```

Optimization of 3-Ring Filter



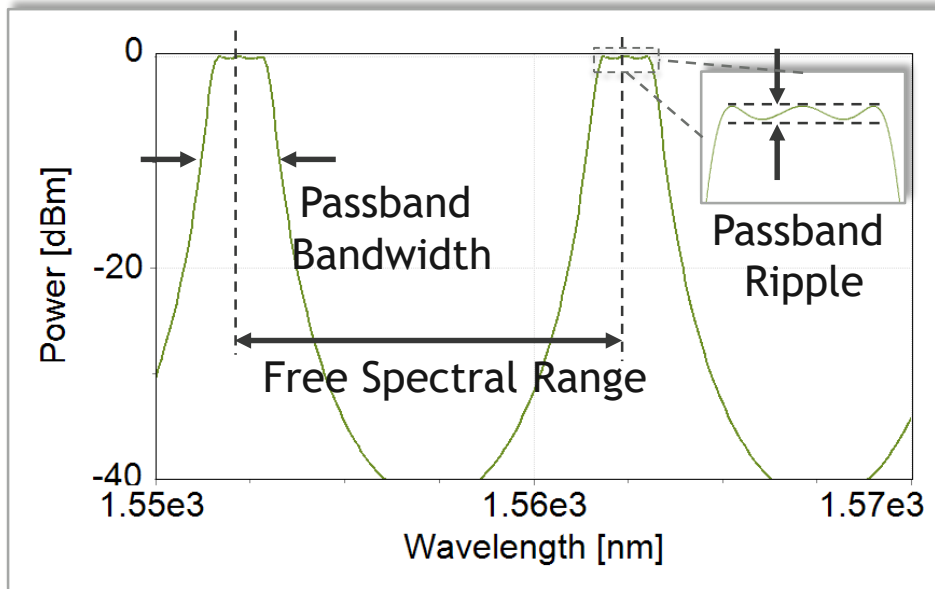
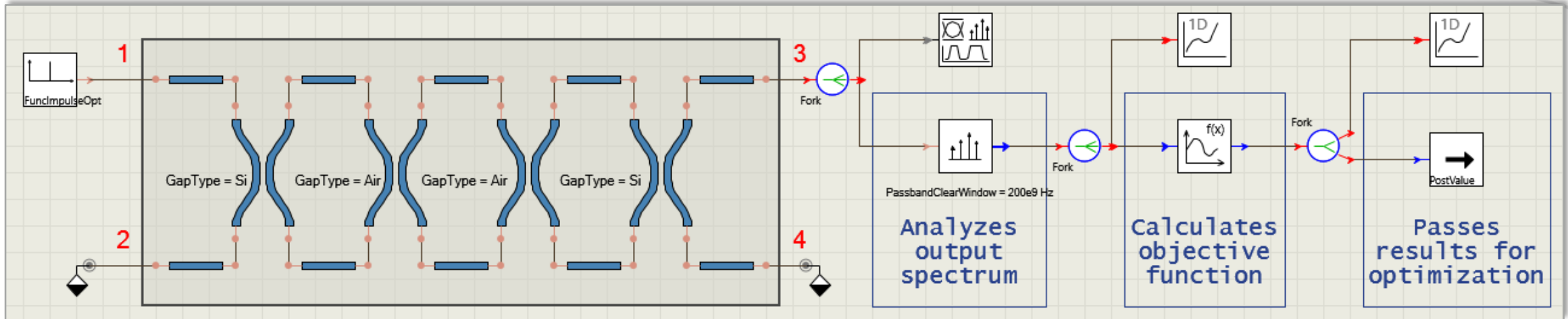
Desired filter performance



Find optimum circuit parameters that

- ✓ Meet design specifications (e.g. flat pass band, desired bandwidth, FSR)
- ✓ Provide min sensitivity to fabrication imperfections and high yield

- ⇒ Multi-parameter optimization
- ⇒ Monte-Carlo simulations (high effort)
- ⇒ Corner analysis, Sensitivity analysis, Yield analysis



Custom optimization routines (in Python or Tcl) could be used. Differential evolution method implemented in SciPy is used::

```

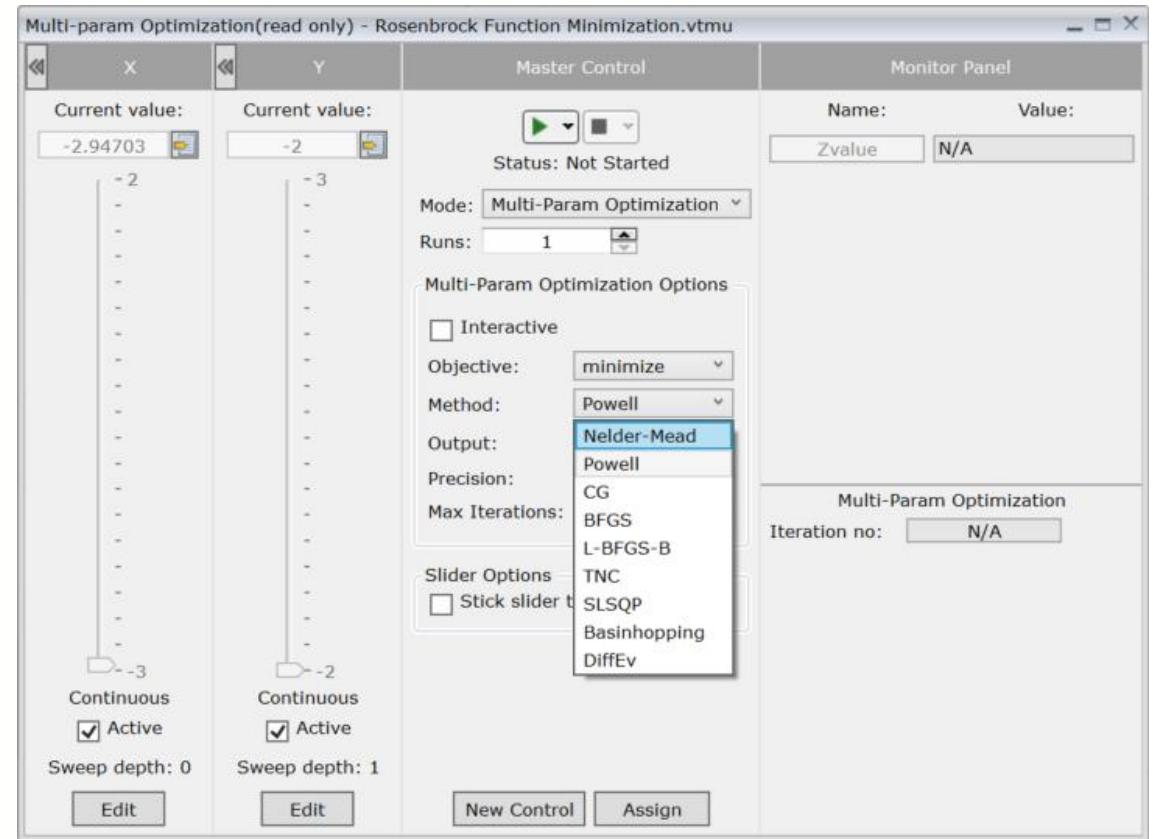
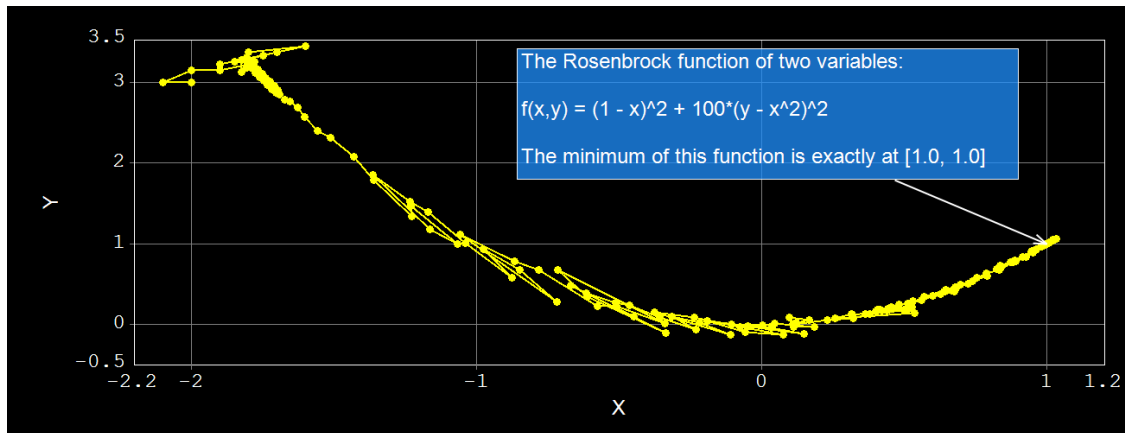
simulation_script.tcl
1 pythonScript {
2   import vpi_ptcl_script as vpi
3   from scipy.optimize import differential_evolution
4   def RunOnce (x) :
5       vpi.setstate('this', 'AirGapWidth', x[0])
6       vpi.setstate('this', 'RingLengthCorrection', x[1])
7       vpi.run(1)
8       objective_function = vpi.statevalue('ObjectiveFunction', 'InputValue')
9       return objective_function
10  res = differential_evolution(RunOnce, bounds = [(20,120),(-300,300)])
11  vpi.ptclmessage("Global optimization result:"+str(res.x))
12 }

```

Pyt length: 472 lines: 12 Ln: 1 Col: 1 Sel: 0|0 Windows (CR LF) UTF-8 INS

Automatic definition of the schematic parameters providing optimum performance of the design

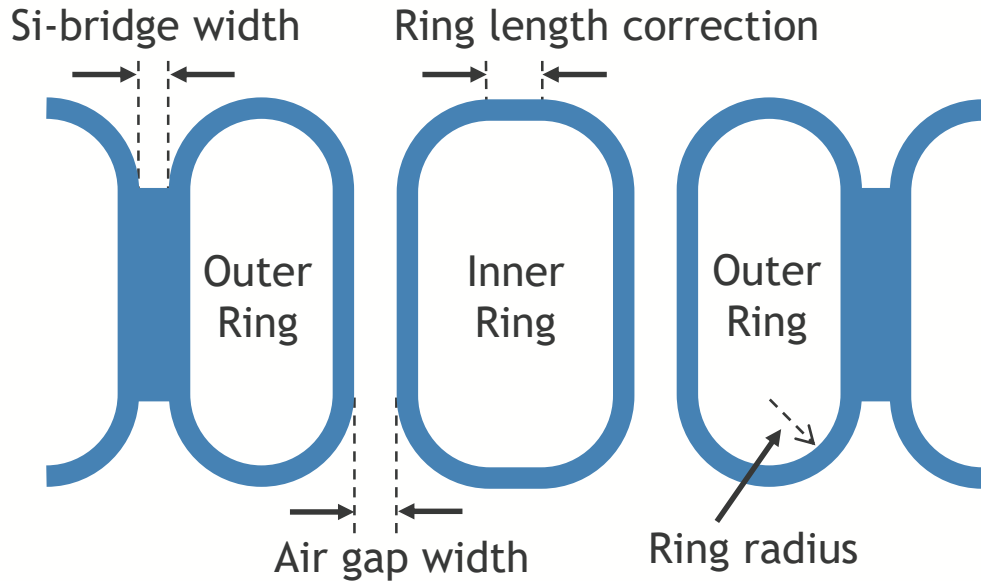
- Commonly used optimization algorithms
- Control precision and maximum number of iterations



Design of Photonic Circuits using PDKs

Design Robustness & Sensitivity

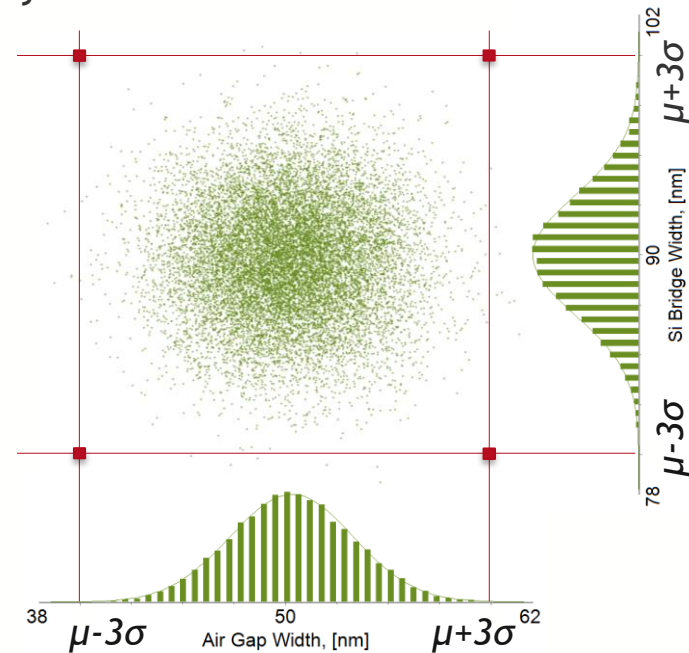
Optimization of 3-Ring Filter



Find optimum circuit parameters that

- ✓ Meet design specifications (e.g. flat pass band, desired bandwidth, FSR)
- ✓ Provide min sensitivity to fabrication imperfections

Corner Analysis

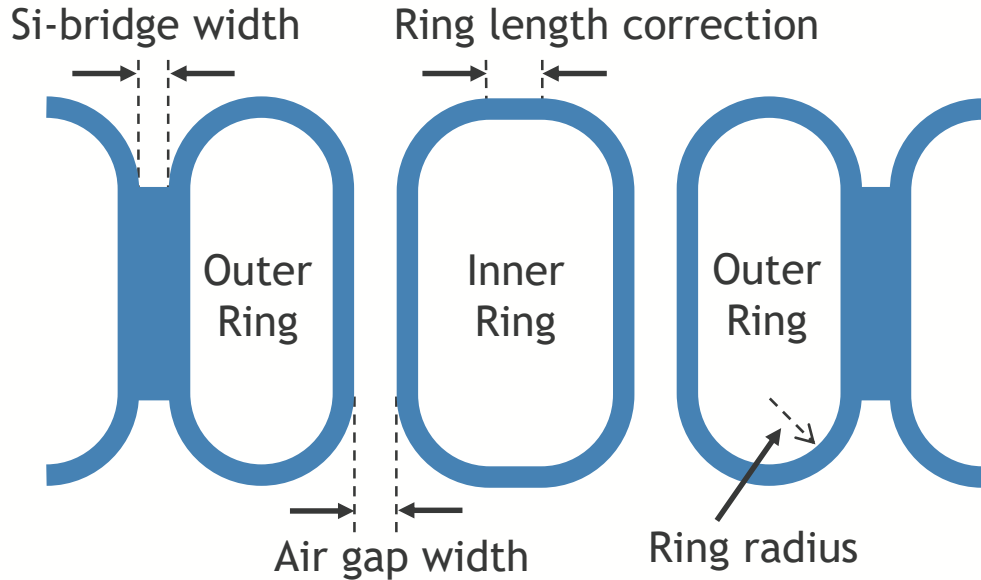


- ✓ Verify circuit robustness with comparatively small number of tests
- ✓ Verify that circuit performance characteristics falls within specification limits

Design of Photonic Circuits using PDKs

Design Robustness & Sensitivity

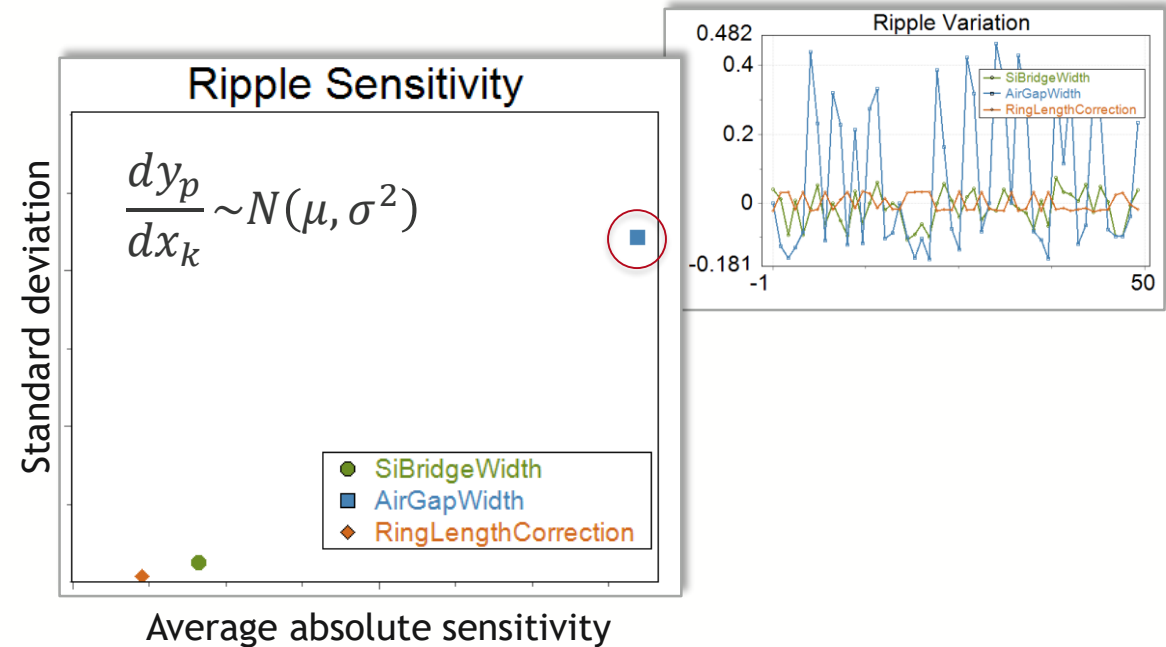
Optimization of 3-Ring Filter



Find optimum circuit parameters that

- ✓ Meet design specifications (e.g. flat pass band, desired bandwidth, FSR)
- ✓ Provide min sensitivity to fabrication imperfections

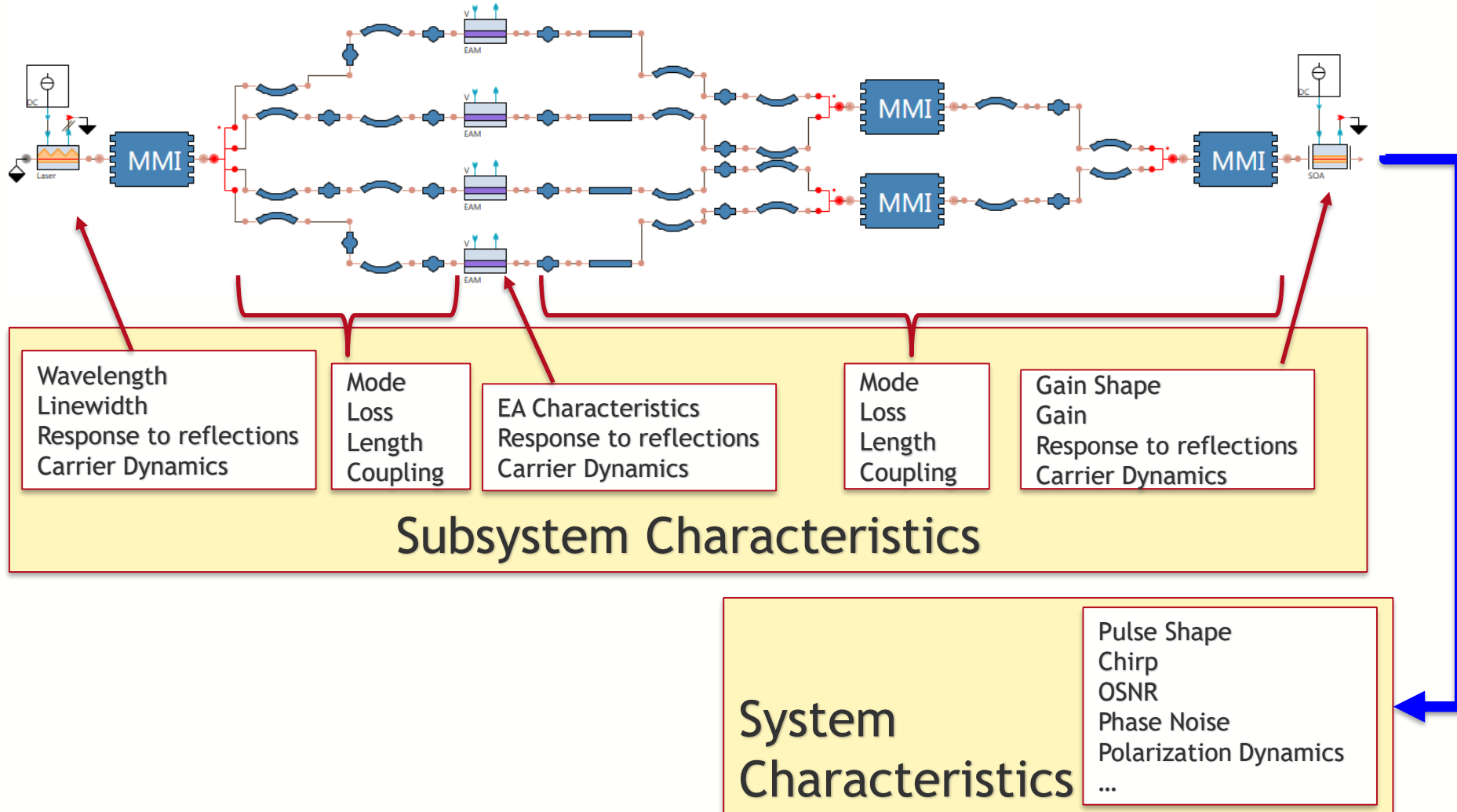
Sensitivity Analysis

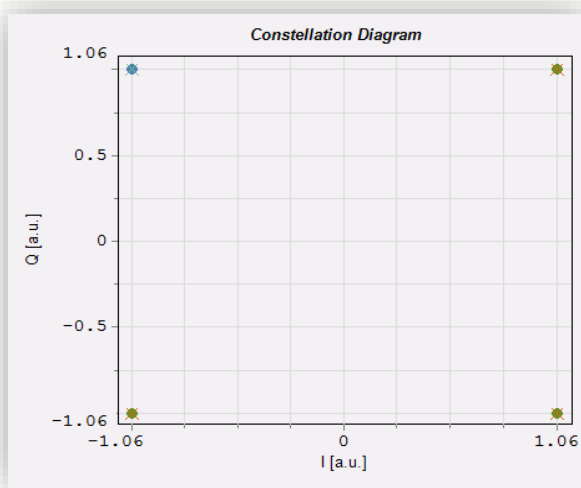
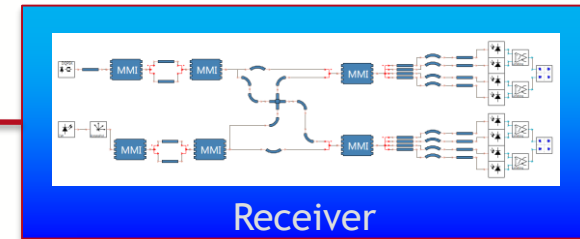
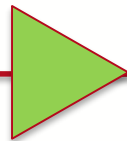
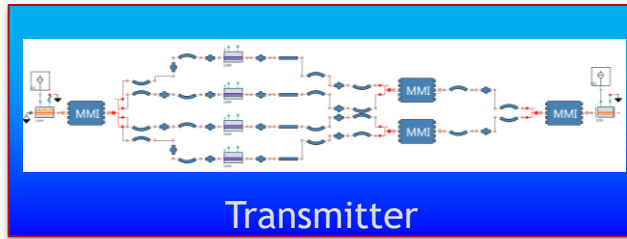


- ✓ Vary one parameter at a time (for different start conditions of other parameters)
- ✓ Determine its impact on circuit performance characteristics

System-level performance verification

IQ Transmitter

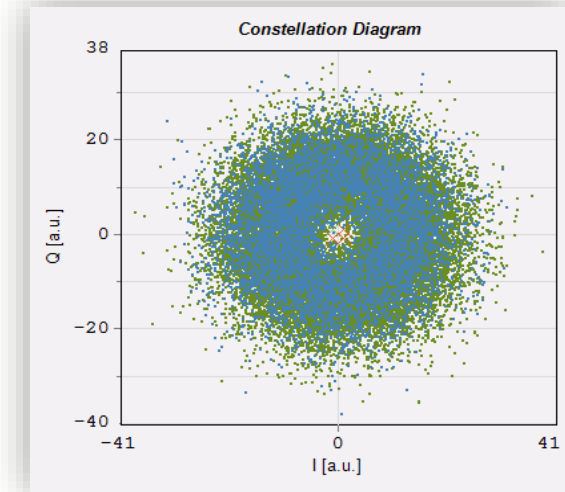




EDFA
Gain
Noise

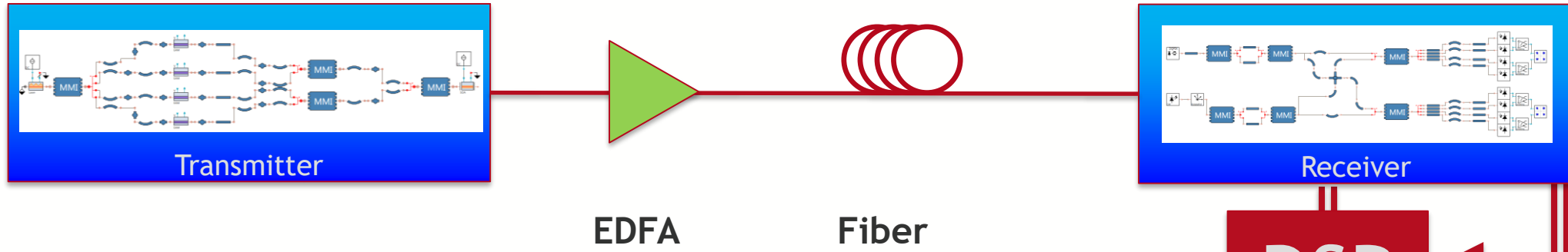
Fiber
Loss
Dispersion
Nonlinearities
PMD

•
•
•



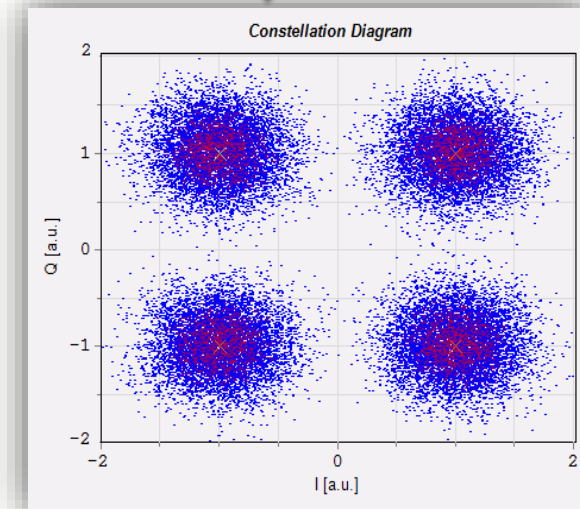
This tells us **NOTHING**
about end to end
performance

- The EDFA affects OSNR
- With the addition of fiber, things get interesting: Loss, Dispersion, SPM, XPM, FWM, Interaction of Noise and Signal



DSP needed

- Dispersion
- LO Frequency Offset
- Phase Tracking
- Polarization Crosstalk
- Synchronization
- Filtering



Use off-the-shelf components to perform the full system simulation for:

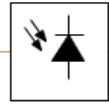
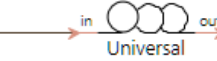
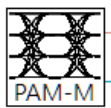
- Verification
- Benchmarking
- Yield estimate and sensitivity analysis
- Troubleshooting problems

Design without system modeling is risky!

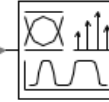
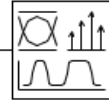
PAM-4 Tx under Test
(DAC, el. driver, CW laser, MZM)

TDEC* Assessment of PAM-4 Transmitters

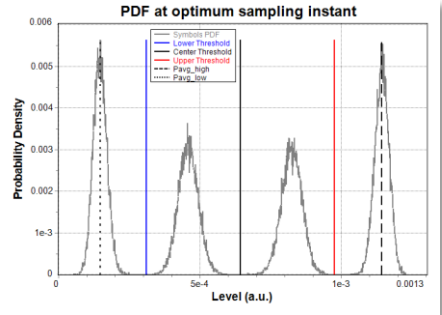
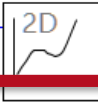
PAM-4 Source



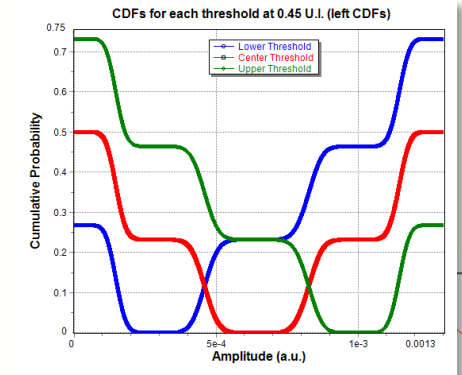
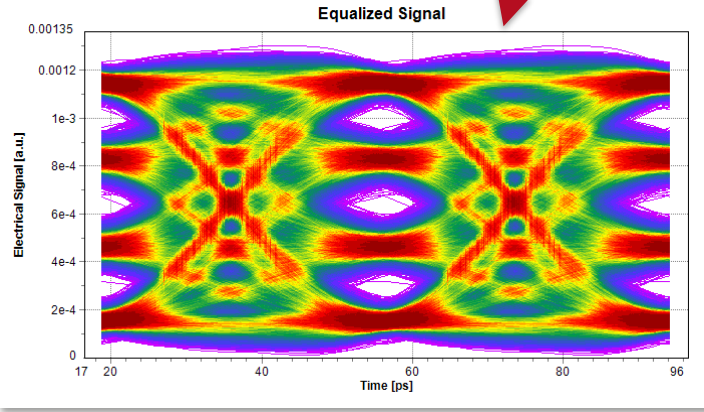
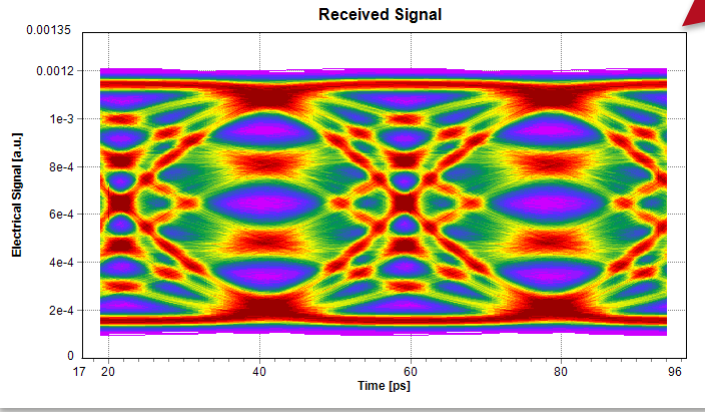
TransferFunction = Bessel
Bandwidth = SymbolRate/2 Hz
FilterOrder = 4



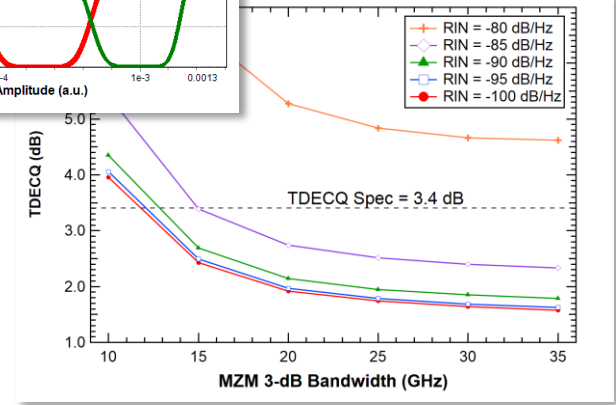
Const



SSPRQ Sequence



Visualization of performance characteristics



- Reference equalizer taps updated with MMSE criterion
- Calculates equalization noise enhancement factor
- OMA and thresholds can be determined automatically

* TDEC - Transmitter and Dispersion Eye Closure, defined in IEEE P802.3bs/D2.2 Draft Standard for Ethernet Amendment 10: Media Access Control Parameters, Physical Layers and Management Parameters for 200 Gb/s and 400 Gb/s Operation

- ✓ Accurate parametrized models of passive and optoelectronic components (including SOAs, DBR/DFB lasers and etc.)
- ✓ Multi-domain simulation engines
- ✓ Seamless integration of circuit and layout design tools with layout aware simulation
- ✓ Integration of circuit- and device-level simulations

Definition of PDK libraries with validated models for active and passive photonic circuits.

- ✓ Automated means for sweeps, optimizations, sensitivity analysis
- ✓ Scripting capabilities for automation of repeating tasks

Design for manufacturing: development of circuits resistance to device/circuit/system variation

- ✓ Integration of circuit- and system-level simulations

System verification and electronic-photonic synergy